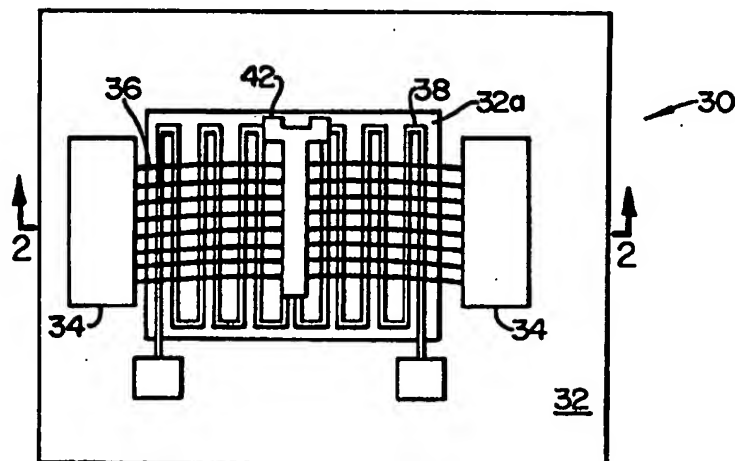




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(54) Title: **THERMAL ARCHED BEAM MICROELECTROMECHANICAL DEVICES AND ASSOCIATED FABRICATION METHODS**



(57) Abstract

A MEMS actuator is provided that produces significant forces and displacements while consuming a reasonable amount of power. The MEMS actuator includes a microelectronic substrate, spaced apart supports on the substrate and a metallic arched beam extending between the spaced apart supports. The MEMS actuator also includes a heater for heating the arched beam to cause further arching of the beam. In order to effectively transfer heat from the heater to the metallic arched beam, the metallic arched beam extends over and is spaced, albeit slightly, from the heater. As such, the MEMS actuator effectively converts the heat generated by the heater into mechanical motion of the metallic arched beam. A family of other MEMS devices, such as relays, switching arrays and valves, are also provided that include one or more MEMS actuators in order to take advantage of its efficient operating characteristics. In addition, a method of fabricating a MEMS actuator is further provided.

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THERMAL ARCHED BEAM MICROELECTROMECHANICAL DEVICES AND ASSOCIATED FABRICATION METHODS

Related Application

This patent application is a continuation-in-part of U.S. Patent Application Serial No. 08/767,192 which was filed on December 16, 1996, the contents of which are expressly incorporated in their entirety
5 herein.

Field of the Invention

The present invention relates generally to microelectromechanical devices and, more particularly,
10 to microelectromechanical devices that include thermal arched beam actuators and related fabrication methods.

Background of the Invention

Microelectromechanical systems (MEMS) have recently been developed as alternatives for
15 conventional electromechanical devices such as relays, actuators, valves and sensors. MEMS devices are potentially low cost devices, due to the use of microelectronic fabrication techniques. New functionality may also be provided because MEMS devices
20 can be much smaller than conventional electromechanical devices.

Many potential applications of MEMS technology utilize MEMS actuators. For example, many sensors, valves and positioners use actuators for
25 movement. If properly designed, MEMS actuators can produce useful forces and displacement, while consuming reasonable amounts of power. Many configurations of MEMS actuators have been proposed. For example, U.S. Patent No. 5,475,318 to Marcus et al. entitled
30 "Microprobe", discloses cantilever bimorph microprobes and doubly supported beam bimorph microprobes. In addition, an article entitled "Silicon Fusion Bonding

and Deep Reactive Ion Etching; A New Technology For Microstructures", by Erno H. Klaassen, et al. presented at the International Conference on Solid-State Sensors and Actuators, Transducers '95 held in Stockholm, Sweden in June 1995 describes a thermal actuator having a pair of arched beams extending between a pair of supports. By current through the arched beams, the arched beams will expand so as to further arch. The thermal actuator of the Klaassen article can also include a center post that connects the plurality of arched beams and serves to push against the workpiece. The Klaassen article also describes a capacitive accelerometer structure that utilizes the thermal actuators to vary the spacing between a number of interdigitated fingers.

Notwithstanding the MEMS actuators that have previously been proposed, a number of existing and contemplated MEMS systems, such as relays, actuators, valves and sensors, require more sophisticated actuators that provide useful forces and displacements while consuming reasonable amounts of power in an efficient manner. Since it is desirable that the resulting MEMS systems be fabricated with batch processing, it is also preferred that the microelectronic fabrication techniques for manufacturing the resulting MEMS systems be affordable, repeatable and reliable.

Summary of the Invention

The MEMS devices of the present invention include a particularly advantageous MEMS actuator, as well as a family of other MEMS devices, such as relays, switching arrays and valves, that include one or more MEMS actuators. In addition, a method of fabricating a MEMS actuator is also provided according to the present invention.

According to the present invention, a MEMS structure, hereinafter referred to as a MEMS actuator,

includes a microelectronic substrate, spaced apart supports on the substrate and a metallic arched beam extending between the spaced apart supports. The MEMS actuator also includes means for heating the arched beam to cause further arching of the beam. Preferably, the heating means includes a heater extending between first and second opposed ends which, in turn, are disposed upon the microelectronic substrate.

In order to effectively transfer heat from the heater to the metallic arched beam, the metallic arched beam extends over and is spaced, albeit slightly, from the heater such that the heat generated by the heater causes the metallic arched beam to further arch. As such, the MEMS actuator of this advantageous embodiment effectively converts the heat generated by the heater into mechanical motion of the metallic arched beam. As described herein, numerous MEMS devices can incorporate the MEMS actuator of the present invention in order to provide a controllable force and displacement without consuming significant amounts of power.

The heater preferably includes an at least partially conductive material having high resistivity, such as polysilicon, titanium or tungsten, surrounded by a dielectric material, such as silicon nitride or silicon dioxide. The dielectric material surrounding the at least partially conductive material cooperates with an air gap defined between the metallic arched beam and the heater to electrically isolate the metallic arched beam from the at least partially conductive material. In order to effectively transfer the thermal energy generated by the heater to the metallic arched beam, the air gap is preferably small, such as less than about 5 microns and, more preferably, between about 1 micron and 2 microns. Likewise, the dielectric material is also preferably relative thin.

and, in one advantageous embodiment, has a thickness of about 0.5 micron.

5 The MEMS actuator also preferably includes a lengthwise extending actuator member connected to the metallic arched beam and extending outwardly in a first direction. According to one advantageous embodiment, the heater underlies and is aligned with the actuator member in the first direction. As a result of this alignment, the heat generated by the heater of this
10 embodiment is even more efficiently transmitted to the actuator member and, in turn, to the metallic arched beam so as to cause further arching of the arched beam.

A number of MEMS devices have also been developed according to the present invention that
15 utilize one or more MEMS actuators for providing useful forces and displacements while consuming reasonable amounts of power. For example, a MEMS relay of the present invention includes a microelectronic substrate, a first pair of contacts on the substrate and a first
20 MEMS actuator on the substrate for controllably establishing electrical contact between the pair of contacts. The actuator member of the MEMS actuator preferably includes a lengthwise extending portion coupled to the arched beam and an enlarged contact
25 portion, responsive to movement of the lengthwise extending portion, for establishing contact with the first pair of contacts. According to one embodiment, the actuator member, including the lengthwise extending portion and the enlarged contact portion, is a unitary
30 structures. According to another embodiment, however, the lengthwise extending portion and the enlarged contact portion of the actuator members are separate structures positioned such that the lengthwise extending portion will move into contact with the
35 enlarged contact portion upon movement of the lengthwise extending portion in response to heating of

the arched beams, thereby urging the enlarged contact portion into contact with the first pair of contacts.

Upon actuation of the MEMS relay of the present invention, the actuator member is moved between
5 an open position in which the actuator member is spaced from the first pair of contacts and a closed position in which the actuator member contacts the first pair of contacts and establishes an electrical connection therebetween. In order to further reduce the power
10 requirements of the MEMS relay, the MEMS relay preferably includes means for holding the actuator member in position following heating of the arched beam and movement of the actuator member. The holding means can include means for applying an electrostatic force
15 between the actuator member and the substrate, thereby holding at least a portion of the actuator member against the substrate.

The MEMS relay can also include at least one retaining member on the substrate and positioned so as
20 to underlie the actuator member once the actuator member has moved in response to heating of the arched beam. According to this advantageous embodiment, the actuator member also includes a lower surface facing the substrate that defines at least one recess for
25 cooperably receiving a respective retaining member as the actuator member is held in position, such as by an electrostatic force.

Alternatively, the MEMS relay can include latch means for latching the actuator member in
30 position following heating of the arched beam and movement of the actuator member. By latching the actuator member in position, electrical contact will be maintained between the first pair of contacts without having to continue actuating the MEMS actuator, thereby
35 further reducing power requirements of the MEMS relay. According to one advantageous embodiment, the latch means includes a projection extending outwardly from

the actuator member and an associated latch member for cooperably engaging the outwardly extending projection upon actuation of the MEMS actuator. The MEMS relay of this embodiment can also include reset means, typically
5 including a second MEMS actuator having an actuator member that includes the latch member, for disengaging the latch member from the outwardly extending projection, thereby permitting the MEMS relay to return to a rest position.

10 In order to provide improved overvoltage protection, the MEMS relay can also include first and second field intensification structures electrically connected to respective ones of the first pair of contacts. The first and second field intensification
15 structures are disposed in a facing relationship to thereby define a discharge gap. Preferably, each field intensification structure includes at least one pointed protection extending toward the other field intensification structure to more precisely define the
20 discharge gap.

According to one embodiment, the MEMS relay includes a second MEMS actuator on a portion of the substrate opposite the first MEMS actuator relative to the first pair of contacts. The second MEMS actuator
25 is designed to controllably disengage the actuator member of the first MEMS actuator from the first pair of contacts in order to reopen the first pair of contacts. Upon heating the arched beam of the second MEMS actuator, the actuator member of the second MEMS
30 actuator preferably moves so as to contact the actuator member of the first MEMS actuator, thereby disengaging the actuator member of the first MEMS actuator from the first pair of contacts.

The MEMS relay of another advantageous
35 embodiment alternately connects first and second pairs contacts. The MEMS relay of this embodiment includes a substrate, first and second pairs contacts on the

substrate and first and second MEMS actuators on the substrate. The MEMS actuators are positioned such that upon actuation of the first MEMS actuator, the actuator member of the first MEMS actuator cooperably engages
5 the actuator member of the second MEMS actuator. Once engaged, electrical contact is established between the first pair of contacts in the absence of further actuation of either MEMS actuator. In contrast, electrical contact is only established between the
10 second pair of contacts upon actuation of the second MEMS actuator.

The end portion of the actuator member of the second MEMS actuator preferably includes a sleeve that opens through the end thereof. Correspondingly, the
15 end portion of the actuator member of the first MEMS actuator preferably includes an engagement portion for insertion through the end of the sleeve upon actuation of the first MEMS actuator. As such, the actuator members of the first and second MEMS actuators will
20 remain cooperably engaged following the actuation of the first MEMS actuator.

Building upon the MEMS relays described above, a MEMS switching array is also provided that includes a substrate and a plurality of first and
25 second MEMS actuators positioned on the substrate such that the plurality of first MEMS actuators define respective row elements and the plurality of second MEMS actuator define respective column elements. According to this embodiment, each MEMS actuator also
30 includes a plurality of contact members spaced along the respective actuator member and extending outwardly therefrom. Upon actuation of a pair of first and second MEMS actuators, the respective actuator members are moved so as to establish electrical contact between
35 the respective contact members, thereby establishing a continuous electrical path between the pair of first and second MEMS actuators.

The MEMS switching array can also include latch means for latching the actuator members of the respective pair of first and second MEMS actuators in position following actuation thereof. As such,
5 electrical contact will be maintained between the respective contact members without having to continue actuating the respective pair of first and second MEMS actuators, thereby further reducing power requirements of the MEMS switching array. According to one
10 advantageous embodiment, the latch means includes a latch member extending outwardly from each respective actuator member and a plurality of anchor members. Each anchor member is associated with a respective MEMS actuator and is positioned upon the substrate so as to
15 cooperably engage the latch member upon actuation of the respective MEMS actuator.

The MEMS switching array can also include reset means for unlatching the actuator members of the respective pair of first and second MEMS actuators such
20 that respective contact members separate and no longer make electrical contact in the absence of further actuation of the respective pair of first and second MEMS actuators. Advantageously, the reset means includes first and second reset actuators for resetting
25 the plurality of first MEMS actuators and the plurality of second MEMS actuators, respectively. In addition, each reset actuator preferably includes an actuator member having a plurality of reset members spaced therealong. The plurality of reset members engage
30 respective actuator members of the first and second MEMS actuators upon actuation of the reset actuator, thereby disengaging the latch portions of the actuator members from the respective anchor members.

According to another aspect of the present
35 invention, a MEMS valve is provided that includes a substrate defining an opening and a MEMS actuator on the substrate and having a valve plate operably coupled

to the arched beam, either directly or indirectly via an actuator member, that is adapted to at least partially covering the opening in the substrate. As such, the portion of the opening covered by the valve plate can be precisely controlled by moving the valve plate relative to the substrate upon actuation of the MEMS actuator. In order to further reduce the power consumed by the MEMS valve of the present invention, the MEMS valve can also include means for holding the valve plate in position relative to the opening without requiring further actuation of the arched beam.

In order to increase the flow rate of the MEMS valve, the substrate preferably defines a plurality of openings and the MEMS actuator correspondingly includes a plurality of valve plates operably coupled to the arched beam and adapted to at least partially cover respective ones of the openings. In order to increase the size of the openings, thereby further increasing the flow rate of the MEMS valve, the valve plate is preferably designed as an elongate plate that pivots about a pivot point, typically defined by a bearing post extending outwardly from the substrate, as the arched beam is heated in order to controllably adjust the portion of the opening covered by the valve plate. According to this embodiment, the openings defined by the substrate are preferably spaced angularly about the bearing post. As such, the MEMS valve of this embodiment has the general appearance of a fan with the pivoting valve plates serving as the fan blades. The MEMS valve of this embodiment can be designed to be either normally open or normally closed.

The present invention also provides an advantageous method for fabricating a MEMS structure, such as a MEMS actuator, that includes a metallic arched beam that overlies and is spaced from a heater. According to this method, a sacrificial plating base is initially deposited upon a first surface of a

microelectronic substrate. Thereafter, a photoresist layer is deposited on the sacrificial plating base and is patterned to open one or more windows to the sacrificial plating base. The windows preferably
5 correspond to the pair of spaced apart supports and the arched beam extending between the spaced apart supports of the resulting MEMS actuator. Thereafter, a metal, such as nickel, is electroplated within the windows defined by the photoresist layer to form the pair of
10 spaced apart supports and the arched beams extending between spaced apart supports. The photoresist layer is thereafter removed and portions of the sacrificial plating base are etched to thereby release the arched beams from the substrate.

15 As an alternative to removing all of the plating base that underlies the arched beam in order to release the arched beam, an oxide layer can be formed and patterned so as to underlie the arched beam, but not the spaced apart supports. As such, removal of
20 this oxide layer will release the arched beam from the substrate.

Prior to the depositing the sacrificial plating base upon the substrate, a heater can be formed on the first surface of the substrate. In addition, a
25 cavity can be etched into the portion of the substrate underlying the heater, typically following the removal of the photoresist layer and the etching of the sacrificial plating base and/or the oxide layer, such that medial portions of the heater are further
30 thermally isolated from the substrate.

By fabricating a MEMS structure according to the method of the present invention, metallic arched beams having large aspect ratios can be electroplated over a heater with a relatively small, typically 5
35 microns or less, spacing or air gap between the heater and the overlying metallic arched beam. As a result, heat generated by the heater is effectively transferred

to the metallic arched beam for translation into mechanical motion of the arched beam. In addition, concurrent with the fabrication of a MEMS actuator as described above, the method of the present invention
5 can also advantageously cofabricate the other portions of the MEMS structures of the present invention, such as the MEMS relays, the MEMS switching arrays and the MEMS valves.

As described above, MEMS structures,
10 including the MEMS actuators, of the present invention provide significant forces and displacements while consuming reasonable amounts of power. In particular, the design of the MEMS actuator of the present invention provides efficient thermal transfer of the
15 heat generated by the heater to the overlying metallic arched beam so as to create further arching of the metallic arched beam. In order to capitalize upon the efficient operation of the MEMS actuator of the present invention, a number of MEMS devices, such as a variety
20 of MEMS relays, MEMS switching arrays and MEMS valves, are also advantageously provided.

Brief Description of the Drawings

Figure 1 is a top view of a MEMS actuator of one embodiment of the present invention that includes a
25 heater for causing the beams to further arch.

Figure 2 is a cross-sectional view of the MEMS actuator of Figure 1 taken along line 2-2 in which the dashed lines indicate the plurality of branches of the sinuous heater, two of which are illustrated for
30 purposes of discussion.

Figure 3 is a MEMS actuator according to another embodiment of the present invention having a heater that underlies the actuator member.

Figure 4 is a cross-sectional view of the
35 MEMS actuator of Figure 3 taken along line 4-4.

Figures 5A-5E are cross-sectional views illustrating the operations performed during the fabrication of a MEMS actuator of one embodiment of the present invention.

5 Figures 6A-6F are cross-sectional views illustrating the operations performed during the fabrication of a MEMS actuator of another embodiment of the present invention.

10 Figure 7A is a top view and Figures 7B and 7C are cross-sectional views of a MEMS relay in an open position wherein the MEMS relay includes a MEMS actuator according to one embodiment of the present invention.

15 Figure 8A is a top view and Figures 8B and 8C are cross-sectional views of a MEMS relay in a closed position wherein the MEMS relay includes a MEMS actuator according to one embodiment of the present invention.

20 Figures 9A-9C are top views of a MEMS relay including a MEMS actuator according to another embodiment of the present invention that illustrates the sequential operations performed to close and open the MEMS relay.

25 Figure 10 is top view of a portion of a MEMS relay of one embodiment of the present invention that includes first and second field intensification structures for providing overvoltage protection.

30 Figure 11 is a top view of a MEMS relay of another embodiment of the present invention that includes latch means and reset means.

 Figure 12 is a top view of a MEMS relay of another advantageous embodiment of the present invention.

35 Figure 13 is top view of a MEMS relay of yet another advantageous embodiment of the present invention.

Figure 14 is an enlarged plan view of a portion of the MEMS relay of Figure 13 illustrating one advantageous embodiment of the latch means.

5 Figure 15 is a top view of a 4 X 4 switching array in the open position according to one advantageous embodiment of the present invention.

10 Figure 16 is an enlarged perspective view of a portion of the switching array of Figure 15 illustrating one technique for permitting the actuator members of the first and second actuators to cross over.

Figure 17 is a top view of the switching array of Figure 15 in which electrical contact has been established between the first row and the third column.

15 Figure 18 is a top view of a MEMS valve of one embodiment of the present invention.

Figures 19 are cross-sectional views of Figure 18 taken along line 19-19 in the open and closed positions, respectively.

20 Figure 20 is a top view of a normally open fan-type MEMS valve according to another advantageous embodiment of the present invention.

25 Figure 21 is a top view of a normally closed fan-type MEMS valve according to another advantageous embodiment of the present invention.

Detailed Description of the Preferred Embodiments

The present invention now will be described more fully hereinafter with reference to the accompanying drawings, in which preferred embodiments of the invention are shown. This invention may, however, be embodied in many different forms and should not be construed as limited to the embodiments set forth herein; rather, these embodiments are provided so that this disclosure will be thorough and complete, and will fully convey the scope of the invention to those skilled in the art. Like numbers refer to like elements throughout.

30
35

Referring now to Figure 1, a first embodiment of a MEMS structure according to the present invention as illustrated. Although the MEMS structure can be employed for a variety of purposes, including sensing and actuation, the MEMS structure will be hereinafter referred to as a MEMS actuator 30 for sake of clarity. The MEMS actuator includes a microelectronic substrate 32 and a pair of spaced apart supports 34 on the substrate. While the substrate can be formed of a variety of materials, the substrate is typically formed of silicon, glass or quartz.

The spaced apart supports 34 are preferably formed of metal, such as nickel, that is deposited on the substrate 32 by means of an electroplating process in order to have a high aspect ratio, as described hereinbelow. As known to those skilled in the art, electroplating techniques include, but are not limited to "LIGA" techniques.

The MEMS actuator 30 also includes at least one and, more preferably, a number of arched beams 36 extending between the spaced apart supports 34. Although the MEMS actuator can have any number and any size of arched beams, the MEMS actuator of one embodiment includes five arched beams which are 5 μ m wide, 30 μ m tall and 2mm in length. The arched beams are also typically formed of a conductive material which has a positive coefficient of thermal expansion so that the arched beam expands as the arched beam is heated. In particular, the arched beams are preferably formed of a metal and, more preferably, are formed of nickel or a nickel-phosphorous alloy. As described above in conjunction with the spaced apart supports, the arched beams are also preferably formed by electroplating so as to have high aspect ratios. For example, the aspect ratio of the arched beams is preferably greater than 1.5:1 and more preferably is about 3:1. As shown in Figure 1, the arched beams are

arched in a direction which preferably extends parallel to the substrate 32. Although the arched beam is freed from the substrate, typically by means of a release layer and wet etching as described hereinbelow, the
5 arched beam remains anchored at the spaced apart support and is arched toward the desired or predetermined direction of motion.

The MEMS actuator 30 also includes means for applying heat to the arched beams 36. The applied heat
10 causes further arching of the beam as a result of the thermal expansion of the beam. The arching of the beam preferably occurs in the predetermined direction of motion so as to cause displacement of the arched beam. While a variety of techniques can be employed to heat
15 the arched beam, the MEMS actuator of the illustrated embodiment includes an external heater 38. The external heater extends between first and second opposed ends that commonly serve as contact pads for establishing electrical contact with the heater. As
20 shown in Figure 1, the heater of one advantageous embodiment winds back and forth in a sinuous path beneath the metallic arched beams such that heat generated by the sinuous heater heats the metallic arched beams in a relatively even fashion.

Although the first and second ends of the heater 38 are disposed on the substrate 32, a portion of the substrate underlying the remainder of the heater, i.e., the medial portion of the heater, can be etched or otherwise removed in order to further
30 thermally isolate the heater from the substrate, as described hereinbelow and as shown in Figure 2. As shown in Figure 1, the heater can extend in a cantilevered fashion over the cavity 32a defined within the substrate or, alternatively, the cavity defined by
35 the substrate may be covered by a diaphragm, typically formed of a dielectric material such as silicon nitride, in order to structurally support the heater

while maintaining sufficient thermal isolation between the heater and the substrate. Although not shown, a medial portion of the heater extending over the cavity defined in the substrate can be further supported by
5 link, typically also formed of a dielectric material such as silicon nitride, that bridges between the heater and another portion of the substrate.

As described hereinbelow, the heater 38 generally includes a core 38a formed of an at least
10 partially conductive material having a high resistivity, such as resistivity of at least $5 \times 10^{-6} \Omega \cdot \text{cm}$, and a coating 38b formed of a dielectric material surrounding the at least partially conductive material. In one embodiment, the heater includes a core of
15 polysilicon, titanium or tungsten that is surrounded by a coating of silicon nitride or silicon dioxide. As shown in cross-section in Figure 2, the arched beams 36 are electrically isolated from the at least partially conductive core of the heater by a combination of an
20 air gap 40 and the dielectric coating of the heater. In order to transfer heat generated by the heater to the arched beam in the most efficient manner, the air gap is preferably reduced as much as possible while still maintaining sufficient electrical isolation, such
25 as 1,000 volts in one exemplary embodiment. In one advantageous embodiment, the air gap is less than 5 microns and, more preferably, between 1 micron and 2 microns. For the embodiment in which the air gap is between 1 micron and 2 microns, the dielectric material
30 covering the portion of the at least partially conductive material that faces the arched beam has a thickness of about 0.5 micron.

The MEMS actuator 30 of the present invention also preferably includes a lengthwise extending
35 actuator member 42 coupled to the arched beams 36 and extending outwardly therefrom. The actuator member mechanically couples the plurality of arched beams at a

point between the spaced apart supports 34 as shown in Figure 1. As such, further arching of the arched beams in the predetermined direction displaces the actuator member in the same predetermined direction. By
5 configuring multiple arched beams in an array, the resulting MEMS actuator enjoys force multiplication so that a large force and a large displacement may be provided. Moreover, by mechanically connecting multiple beams with the actuator member, the resulting
10 MEMS actuator also enjoys a stiffening effect so as to be capable of providing even higher degrees of force than would be available by these same number of individual arched beams operating independently.

Although the MEMS actuator 30 of the present
15 invention is preferably heated by means of an external heater 38 as described above and shown in Figures 1 and 2, the MEMS actuator can also be heated by passing current through the arched beams 36 or by combination of heating created by the external heater and by
20 passing current through the arched beams. For example, external heating may provide the initial displacement of the MEMS actuator, while internal heating created by passing current through one or more of the arched beams may provide fine motion control. In addition, the MEMS
25 actuator can be heated by external heating means, such as a hot plate, an oven, infra red light, radiation or the like. As such, the MEMS actuator of the present invention can be readily utilized as a temperature sensor or temperature switch.

30 As will be apparent to those skilled in the art, the heater 38 can take a variety of shapes, such as the sinuous heater shown in Figures 1 and 2. In one advantageous embodiment illustrated in Figures 3 and 4, however, the heater underlies and is aligned with the
35 actuator member 42. As described above, the opposed ends of the heater are disposed on the substrate 32. However, the substrate underlying the medial portion of

the heater between the first and second opposed ends is preferably etched or otherwise removed so as to further thermally isolate the heater from the substrate. See Figure 4. In a like fashion to that described above, current can be passed through the heater to generate heat that is efficiently transferred to the arched beams 36 so as to cause further arching, thereby displacing the actuator member in the predetermined direction.

According to the present invention, a fabrication technique is also provided for forming MEMS structures, such as the MEMS actuator 30 having metallic arched beams 36 that is described above and illustrated in Figures 1-4. Although a wide variety of MEMS structures can be fabricated according to this advantageous method, the MEMS actuator depicted in Figures 1 and 2 in which a portion of the substrate underlying the heater 38 is etched or otherwise removed will be hereinafter described for purposes of illustration. Although cavity 32a defined by the substrate of the MEMS actuator of Figures 1 and 2 is open, the cavity could be covered with a diaphragm formed of an insulating material, such as silicon nitride, in order to further support the heater if so desired.

As shown in Figure 5A, a maskant layer 44 of silicon nitride is initially deposited upon the substrate 32 and patterned to open a window corresponding to the cavity which will be eventually formed within the substrate. It will be understood by those having skill in the art that when a layer or element is described herein as being "on" another layer or element, it may be formed directly on the layer, at the top, bottom or side surface area, or one or more intervening layers may be provided between the layers.

After depositing an oxide layer 46, the heater 38 is then fabricated. In this regard, a

silicon nitride layer 48 is deposited and patterned. Thereafter, a polysilicon layer 50 that will form the core 38a of the resulting heater is deposited upon the silicon nitride layer and a second silicon nitride layer 52 is deposited over the polysilicon layer, thereby encapsulating the polysilicon layer with silicon nitride as shown in Figure 5A.

Once the heater 38 has been fabricated, a sacrificial plating base 54 is deposited as shown in Figure 5B. The sacrificial plating base can be any of a variety of plating bases known to those skilled in the art, such as a three layer structure formed of titanium, copper and titanium. Following deposition of the plating base, a thick layer of photoresist 56 is deposited and lithographically patterned to open a number of windows to the sacrificial plating base. See Figure 5C. The windows opened within the photoresist correspond to the various metallic components of the resulting MEMS structure, such as the spaced apart supports 34 and the plurality of arched beams 36 of a MEMS actuator 30. During the fabrication of devices, such as relays, switching arrays and valves, that include the MEMS actuator of the present invention, additional windows can be opened within the photoresist which correspond to other metal structures, such as contacts. The upper titanium layer that is exposed within the windows defined by the patterned photoresist is then etched. Thereafter, a metal 58, such as nickel, copper or gold, is electroplated within the windows defined by the photoresist to produce the intermediate structure shown in Figure 5C. Although any of a variety of metals that are capable of being electroplated can be utilized, nickel is particularly advantageous since nickel has a relatively large thermal coefficient of expansion and since nickel can be deposited with low internal stress in order to further stiffen the resulting structure to out of plane

deflection. Electroplating of nickel layers with low internal stress is described in "The Properties of Electrodeposited Metals and Alloys," H.W. Sapranner, American Electroplaters and Surface Technology Society, pp. 295-315 (1986), the contents of which is
5 incorporated herein in its entirety.

Once the metal 58 has been electroplated, the photoresist 56 is removed. As shown in Figure 5D, the remaining layers of the plating base 54, namely, the
10 copper and the lower titanium layer, are removed so as to release the arched beam 36 from the substrate 32. According to this embodiment, the duration of the etch of the plating base is preferably controlled so that the portion of the plating base underlying the arched
15 beam is removed without removing a significant portion of the plating base that underlies the spaced apart supports 34 such that the arched beams, but not the spaced apart supports, are released from the substrate 32. In embodiments in which a cavity 32a is to be
20 formed in the portion of the substrate underlying the heater 38, the oxide layer 46 is also etched to open a window to the substrate, i.e., the window defined by the maskant 44. By anisotropically etching the substrate, typically with KOH, a cavity can be formed
25 beneath the heater in order to further thermally isolate the heater from the substrate. See Figure 5E.

An alternative method of fabricating MEMS structures, such as MEMS actuators 30, according to the present invention is illustrated in Figures 6A-6F.
30 Once the heater 38 has been fabricated as shown in Figure 6A and as described above, a second oxide layer 53 is deposited as shown in Figure 6B. Windows are thereafter lithographically defined and etched in the first and second oxide layers at spaced apart locations
35 corresponding to the spaced apart supports 34. As shown in Figures 6C and 6D, a metal layer 55, such as chromium and/or copper, is then deposited within these

5 windows prior to depositing the plating base 54. Once
the metallic components, such as the arched beams and
the spaced apart supports, have been lithographically
defined and electroplated as described above, the
10 exposed portions of the plating base are etched so as
to expose the second oxide layer without significantly
undercutting the metallic components. See Figure 6E.
Thereafter, the first and second oxide layers can be
etched or otherwise removed to release the arched beams
15 36 and the heater, but not the spaced apart supports,
from the substrate 32 as shown in Figure 6F.

According to this embodiment, the arched
beams 36 can be released without having to precisely
time the etch of plating base 54 such that the portion
15 of the plating base underlying the arched beams is
removed without removing a significant portion of the
plating base that underlies the spaced apart supports
34. In addition, the method of this advantageous
embodiment is particularly well suited to forming MEMS
20 structures, such as the MEMS valves described
hereinbelow, in which the metallic component to be
released is larger than the metallic component that
will be supported by the substrate 32.

By fabricating a MEMS actuator 30 according
25 to the advantageous methods described above, metallic
arched beams 36 can be formed which have relatively
high aspect ratios, such as 1.5:1 or greater. By
having relatively high aspect ratios, the arched beams
permit motion in the plane, but are relatively stiff
30 outside of the plane. The fabrication method of the
present invention also permits an external heater 38 to
be formed on a portion of the substrate 32 underlying
the metallic arched beams and to be precisely spaced
from the metallic arch beams by a small air gap 40 such
35 that the heat generated by the heater is efficiently
transferred to the arched beams. In addition,
concurrent with the fabrication of a MEMS actuator as

described above, the method of the present invention can also advantageously cofabricate the other portions of the MEMS structures of the present invention, such as the MEMS relays, the MEMS switching arrays and the MEMS valves, thereby further increasing the efficiency of the fabrication process.

A number of MEMS devices can include the MEMS actuator 30 described herein above in order to take advantage of its efficient operating characteristics. For example, a MEMS relay 60 is also provided according to one embodiment of the present invention. As shown in Figure 7A, a MEMS relay includes a microelectronic substrate 62, a first pair of contacts 64 on the substrate and a MEMS actuator 66 including an actuator member 68 for controllably establishing electrical contact between the first pair of contacts. Typically, the first pair of contacts are metallic pads that may also serve as bonding pads. As will be apparent to those skilled in the art, the first pair of contacts are preferably spaced from the substrate by a dielectric layer, such as a layer of silicon nitride, so as to electrically isolate the first pair of contacts from the substrate. Additionally, while the contacts can be formed of any of a variety of conductive materials, the contacts of one advantageous body are formed of nickel and are coated with a noble metal, such as gold or rhodium, that resists the formation of oxide layers thereon.

In the embodiment illustrated in Figure 7A, the MEMS relay 60 is normally open. That is, the MEMS relay is in an open position if the MEMS actuator 66 has not been actuated and the arched beams 70 have not further arched. Upon heating the arched beams, such as by passing a current through the heater 72, the arched beams further arch, thereby moving the actuator member 68 toward the first pair of contacts 64. According to one advantageous embodiment, the actuator member

includes a lengthwise extending portion 68a coupled to the arch beams and an enlarged contact portion 68b for contacting the first pair of contacts. Although one embodiment of the enlarged contact portion is shown in Figure 7A, the enlarged contact portion can have a variety of shapes and sizes. As shown in Figure 8A, further arching of the arch beams causes the enlarged contact portion of the actuator member to establish contact between the first pair of contacts, thereby closing the contact.

In the absence of other forces, the "normally open" MEMS relay 60 of Figures 7 and 8 would return to the open position if the arched beams 70 were no longer heated, such as by no longer passing current through the heater 72. In order to retain the MEMS relay in the closed position as shown in Figure 8A once the arched beams are no longer heated and to improve the vibration/shock resistance of the MEMS relay, the MEMS relay can include means for holding the enlarged contact portion 68b of the actuator member 68 in position, such as the closed position, in the absence of further actuation of the MEMS actuator 66. The means for holding the actuator member in position can include means for applying an electrostatic force between the actuator member and the substrate 62 to thereby draw the actuator member and, more preferably, the enlarged contact portion of the actuator member toward the substrate and to hold at least a portion of the actuator member against the substrate. By holding the actuator member against the substrate, it is contemplated that the actuator member will generally be held against one or more layers, typically including a dielectric layer, that has been deposited upon the surface of the substrate.

As shown in Figures 7B, 7C, 8B and 8C, the means for applying an electrostatic force advantageously includes an electrode 74 disposed on the

surface of the substrate 62. As shown, at least a portion of the electrode is preferably disposed upon the substrate between the first pair of contacts 64. Although the electrode could be buried within the substrate, the electrode of the illustrated embodiment is disposed on the substrate and is separated therefrom by a dielectric layer 76, typically formed of silicon nitride. Upon application of a pull-down voltage to the electrode, the enlarged head portion 68b of the actuator member 68 is pulled downwardly toward the electrode. As illustrated, the electrode is also generally covered with a dielectric layer 78, such as silicon nitride, to insulate the electrode from the enlarged head portion of the actuator member. The air gap between the enlarged head portion of the actuator member and the electrode is preferably sufficiently small, on the order of 1,000-3,000 Angstroms, so that only a few tens of volts may be necessary to clamp the enlarged head portion to the substrate.

Once clamped, the MEMS actuator 66 can be deactivated by halting current flow through the heater 72 and the MEMS relay 60 will remain in a closed position. By holding the MEMS relay in a closed position by the application of electrostatic forces, the power requirements of the MEMS relay are significantly decreased in comparison with the power required to continuously actuate the MEMS actuator.

In order to assist in maintaining the MEMS relay 60 in a closed position, the MEMS relay can also include at least one and, more typically, two or more retaining members 80 that extend across a portion of the substrate 62 which underlies the actuator member 68. For example, the retaining members of the illustrated embodiment are elongate members that extend across a portion of the width of the enlarged head portion of the actuator member. As shown in Figures 7B, 7C, 8B and 8C, the lower surface of the actuator

member facing the substrate preferably includes one or more recesses 82, such as one or more grooves, for receiving respective ones of the retaining members once the MEMS relay is in the closed position and the
5 actuator member has been bent downwardly toward the substrate by a clamp down voltage that has been applied by the electrode 74. The retaining members serve to mechanically engage the actuator member, thereby assisting the electrostatic forces applied by the
10 electrode to retain the MEMS relay in a closed position so long as the actuator member remains clamp to the substrate.

In order to thereafter open the MEMS relay 60, the clamp down voltage applied by the electrode 74
15 is removed such that the actuator member 68 lifts upwardly away from the surface of the substrate 62. The actuator member will then be retracted by means of the restoring forces provided by the arched beams 70 to the open position as shown in Figures 7A-7C. While the
20 MEMS relay of Figure 7 and 8 is a normally open relay as described above, the MEMS relay can be a normally closed relay that is opened only upon actuation of the MEMS actuator 66, such as by heating the arched beams without departing from the spirit and scope of the
25 present invention.

The MEMS relay 60 of the present invention provides numerous advantages in comparison with electrostatic or magnetically actuated microrelays. As a result of the large displacements provided by the
30 MEMS actuator 66 of the present invention, a larger separation can be maintained with the first pair of contacts 64, thereby increasing the standoff voltage capability of the MEMS relay. Additionally, the relatively large forces provided by the MEMS actuator
35 provides good relay or switch closure, thereby ensuring low contact resistance.

Although the actuator member 68 of the MEMS relay 60 described hereinabove can be a unitary structure as shown in Figures 7 and 8, the lengthwise extending portion 68a and the enlarged head portion 68b can be separate structures as shown in Figures 9A-9C. According to this embodiment, the lengthwise extending portion of the actuator member is connected to the plurality of arched beams 70. However, the enlarged head portion is not connected to the lengthwise extending portion of the actuator member. Instead, the enlarged head portion is suspended adjacent to the first pair of contacts 64 by a pair of springs 84 as shown in Figure 9A. Typically, the springs are formed of a metal, such as nickel, during the electroplating step. The springs extend from opposed edges of the enlarged head portion to respective anchor members 86 that extend upwardly from the substrate 62. Typically, the anchor members are spaced from the substrate by means of the plating base and/or a dielectric layer.

Other than the attachment of the anchor members 86 to the substrate 62, the remainder of the enlarged head portion 68b is freed from the substrate. As such, by passing current through the heater 72 and causing the arched beams 70 to further arch, the end portion of the lengthwise extending portion 68a contacts a rear surface of the enlarged head portion and urges the enlarged head portion into contact with the first pair of contacts 64. See Figure 9B. As described above in conjunction with Figure 7 and 8, the MEMS relay 60 of this embodiment can also include means for holding the enlarged head portion of the actuator member in position once current is removed from the heater and the lengthwise extending portion of the actuator member returns to a rest or neutral position as shown in Figure 9C. As shown in Figures 9A-9C, the holding means can include an electrode 74 for applying an electrostatic clamp down force as described above.

Once the clamp down force is removed, however, the enlarged head portion returns to an open position as shown in Figure 9A as a result of the restoring forces provided by the springs 84.

5 As described above in conjunction with the MEMS relay of Figure 7 and 8, the MEMS relay 60 of Figure 9 is described in conjunction with a normally open MEMS relay. However, the MEMS relay of this
10 desired, without departing from the spirit and scope of the present invention.

 According to either embodiment, the MEMS relay 60 can also include first and second field intensification structures 88 for providing overvoltage
15 protection. As illustrated in Figure 10, the first and second field intensification structures are electrically connected to respective ones of the first pair of contacts 64 and are disposed of in a facing relationship relative to one another. More
20 particularly, each field intensification structure preferably includes at least one pointed projection 90 extending toward the other field intensification structure. As such, excessive voltages that build up across the first pair of contacts will not create a
25 spark and break down between the enlarged head portion 68b of the actuator member 68 and the first pair of contacts. Instead, the first and second field intensification structures serve as a fuse by defining a discharge gap which will break down in overvoltage
30 conditions prior to any break down between the enlarged head portion of the actuator member and the first pair of contacts.

 Typically, the field intensification structures 88 are formed of a metal, such as nickel,
35 and are separated from the substrate 62 by means of a dielectric layer, such as silicon nitride. In addition, the pointed projections 90 of each field

intensification structure are generally conical projections that extend to a point as shown in Figure 10. However, the field intensification structures can include other types of projections without departing
5 from the spirit and scope of the present invention.

The MEMS relay 60 can also include latch means for latching the actuator member 68 in position following heating of the arched beams 70 and movement of the actuator member. Heating the arched beams of
10 one embodiment of the MEMS relay will move the MEMS relay from a normally open position as shown in Figure 11 to a closed position in which the actuator member is in electrical contact with the contact members 64. In this regard, the actuator member will make sliding
15 contact with the contact members, thereby at least partially removing any oxide layer that may have developed upon the contact members. Although not illustrated, the MEMS relay can be normally closed, if so desired.

20 The latch means of the MEMS relay 60 of Figure 11 includes a latch member 69 and a corresponding projection 68c extending outwardly from the actuator member such that movement of the actuator member will advance the outwardly extending projection
25 beyond the latch member. As shown, the outwardly extending projection is preferably tapered to facilitate movement of the outwardly extending projection relative to the latch member. Once the outwardly extending projection of the actuator member
30 has advanced beyond the latch member, the latch member preferably engages a shoulder defined by the projection such that the actuator member will remain in position once the MEMS relay is no longer actuated. By latching the actuator member in position, electrical contact
35 will be maintained between the contact members 64 without having to continue actuating the MEMS relay,

thereby further reducing power requirements of the MEMS relay.

5 The MEMS relay 60 of this embodiment can include a bearing 73 that is positioned upon the substrate 62 adjacent the actuator member 68 on the opposite side from the latch member 69. The bearing defines an angled bearing surface 73a that cooperates with a bearing surface 68d defined by the actuator member in order to insure that shoulder of the
10 outwardly extending projection 68c engages the latch member once the projection has been advanced beyond the latch member.

 The MEMS relay 60 of this embodiment also preferably includes reset means for disengaging the
15 latch member 69 and the outwardly extending projection 68c so as to permit the MEMS relay to return to a rest position. As shown in Figure 11, the reset means can include a second MEMS actuator 71 having an actuator member that includes a latch member. As such,
20 actuation of the second MEMS actuator moves the latch member away from the outwardly extending projection such that the latch member and the projection disengage, thereby permitting the MEMS relay to return to the rest position, i.e., the open position in this
25 embodiment, in the absence of further actuation.

 A MEMS relay 92 of another embodiment is illustrated in Figure 12. The MEMS relay of this embodiment includes first and second MEMS actuators disposed on the substrate 94 on opposite sides of the
30 first pair of contacts 96 . In order to establish electrical contact between the first pair of contacts, the first MEMS actuator 98 is actuated, such as by passing current through the heater 100. Upon actuation, the end portion 102a of the actuator member
35 102 of the first MEMS actuator is inserted between the first pair of contacts, thereby establishing electrical contact therebetween.

As shown in Figure 12, the first pair of contacts 96 preferably includes a pair of outwardly extending contact arms 96a that are free from the substrate and extend thereover in a cantilevered fashion. As also shown, the contact arms of the first pair of contacts define a gap having a width that is slightly less than the width of the tapered end portion 102a of the actuator member 102 of the first MEMS actuator 98. As will therefore be apparent, insertion of the tapered end portion of the actuator member between the first pair of contacts upon actuation of the first MEMS actuator will force the respective contact arms apart. As a result, the inward restoring forces of the contact arms will serve to engage the end portion of the actuator member between the contact arms such that the MEMS relay will remain in a closed position, that is, the tapered end portion of the actuator member of the first MEMS actuator will remain held between the first pair of contacts, even after the first MEMS actuator is deactuated.

In order to facilitate insertion of the actuator member 102 between the first pair of contacts 96, the actuator member 102 of the first MEMS actuator 98 preferably has a tapered end portion 102a. See Figure 12. In addition, the edge surfaces of the contact arms 96a that receive and electrically contact the actuator member of the first MEMS actuator are preferably correspondingly tapered. As such, the tapered end portion of the actuator member of the first MEMS actuator will snugly fit between and engage the first pair of contacts.

In order to open the MEMS relay 92 of this advantageous embodiment, the second MEMS actuator 104 is preferably actuated so as to advance the respective actuator member 106. As the actuator member of the second MEMS actuator advances, the end portion of the actuator member will contact the tapered end portion

102a of the actuator member 102 of the first MEMS actuator 98 so as to disengage the tapered end portion of the actuator member of the first MEMS actuator from the first pair of contacts 96. Once disengaged, the restoring forces provided by the arched beams 99 serve to further retract the actuator member of the first MEMS actuator to the neutral position shown in Figure 12.

In order to facilitate contact with the actuator member 102 of the first MEMS actuator 98, the end portion of the actuator member 106 of the second MEMS actuator 104 preferably includes a reduced width portion 106a having a width that is less than the gap between the contact arms 96a. As such, the reduced width portion of the actuator member of the second MEMS actuator can contact the actuator member of the first MEMS actuator without contacting or otherwise engaging the first pair of contacts.

Since the actuator member 102 of the first MEMS actuator 98 is relatively long, the MEMS relay 92 can also include a suspension spring 108 that is connected to the end portion 102a of the actuator member. The suspension spring serves to more precisely position the tapered end portion of the actuator member relative to the first pair of contacts 96 and to assist in the return of the tapered end portion of the first MEMS actuator to a neutral position.

Figure 13 illustrates a MEMS relay 110 of yet another embodiment for alternately connecting first and second pairs of contacts. According to this embodiment, the MEMS relay includes a substrate 112 and first and second pairs of contacts on the substrate. As described above, the contacts are preferably isolated from the substrate, such as by means of a dielectric layer formed of silicon nitride, for example.

The MEMS relay 110 of this embodiment also includes first and second MEMS actuators disposed on the substrate 112 on opposite sides of the first and second pairs of contacts. As shown in Figure 13, the actuator member 116 of the second MEMS actuator 114 extends toward the first and second pairs of contacts and includes an enlarged head portion 116a disposed between the first and second pairs of contacts. The actuator member of the second MEMS actuator also includes a sleeve 116b mounted to the end portion of the actuator member and opening through the end 116c thereof. Correspondingly, the actuator member 120 of the first MEMS actuator 118 preferably includes a somewhat enlarged engagement portion 120a such that actuation of the first MEMS actuator advances the actuator member in a direction towards the second MEMS actuator so as to insert the engagement portion through the end of the sleeve.

As shown in more detail in Figure 14, the open end 116c of the sleeve 116b preferably includes an inwardly extending flange 116d. In addition, the engagement portion 120a of the actuator member 120 of the first MEMS actuator 118 is preferably tapered or flared to facilitate the insertion of the engagement portion through the open end of the sleeve. As also shown in Figure 14, the engagement portion of the actuator member of the first MEMS actuator also preferably defines a shoulder 120b for cooperably engaging the inwardly extending flange of the open end of the sleeve. As such, the actuator members of the first and second MEMS actuators will remain cooperably engaged following deactuation of the first MEMS actuator.

Once the actuator members of the first and second MEMS actuators are cooperably engaged, the restoring forces of the arched beams 122 of the first MEMS actuator 118 will draw the enlarged head portion

116a of the actuator member 116 of the second MEMS actuator 114 into contact with the first pair of contacts 124 if neither MEMS actuator is actuated. As such, the first pair of contacts is referred to as the "normally closed" contact and the second pair of contacts 126 is referred to as the "normally open" contact. By actuating the second MEMS actuator, such as by passing current through the heater 128 underlying the arched beams 130 of the second MEMS actuator, or by concurrently actuating the first and second MEMS actuators, the enlarged head portion can be disengaged from the first pair of contacts and, instead, can be placed in electrical contact with the second pair of contacts. Once the second MEMS actuator is deactivated, however, contact is reestablished with the first pair of contacts, as described above.

According to another aspect of the present invention shown in Figure 15, a plurality of the MEMS actuators can be assembled to define a MEMS switching array 140. According to this embodiment, a number of first and second MEMS actuators are positioned on the substrate 142 such that the first MEMS actuators 144 define respective row elements and the second MEMS actuators 146 define respective column elements. As shown in Figure 15, for example, a first set of four MEMS actuators define four row elements (R0, R1, R2 and R3) and a second set of four MEMS actuators define four column elements (C0, C1, C2 and C3), thereby defining a 4x4 switching array. As will be apparent, the switching array of this embodiment need not have the same number of row and column elements and, in fact, can have any number of row and column elements that are desired. As described below, actuation of a respective pair of first and second MEMS actuators moves the respective actuator members and establishes electrical contact between respective contact members. As a result, a continuous electrical path is established

between the respective pair of first and second MEMS actuators.

5 The actuator member 148 of each MEMS actuator preferably includes a plurality of contact members 150 spaced along the actuator member and extending outwardly therefrom. For a MEMS actuator defining a respective row element, the actuator member preferably includes the same number of contact members as column elements. Likewise, for a MEMS actuator defining a
10 respective column element, the actuator member preferably includes the same number of contact members as row elements. As shown in Figure 15, for example, each actuator member includes four contact members spaced along the actuator member and extending
15 outwardly therefrom. As such, the switching array of the present invention does not require a separate actuator for each switch of the switching array, thereby simplifying the switch design in comparison with some conventional switching arrays.

20 The actuator member 148 of each MEMS actuator preferably extends across the entire array. In order to permit the actuator members of the first and second MEMS actuators to cross, the actuator member of each first MEMS actuator 144 preferably includes a plurality
25 of arched portions 152 to permit the actuator member to cross over the actuator members of the second MEMS actuators 146 as shown in Figure 16. As will be apparent, however, the actuator member of each second MEMS actuator could instead include a plurality of
30 arched portions to permit the actuator member to cross over the actuator members of the first MEMS actuators, if so desired. As shown in Figure 16, the width of the arched portions of the actuator member are preferably sufficient to permit each actuator member to have full
35 freedom of motion and to provide sufficient dielectric isolation. As such, the actuator members of the first MEMS actuators that define respective row elements and

the actuator members of the second MEMS actuators that define respective column elements are free to move relative to one another. Preferably, the arched portions of the actuator member are formed by
5 electroplating a second layer of metal, such as nickel, which connects the remainder of the actuator member that was deposited in a previous electroplating step.

By way of example, the first MEMS actuator 144 that defines the first row element (R0) and the
10 second MEMS actuator 146 that defines the third column element (C2) have been actuated such that electrical contact is established between the respective contact members 150 as circled in Figure 17. In particular, the contact members are preferably moved into contact
15 with a wiping-type motion to thereby remove any oxide that may have formed on the surfaces of the respective contact members. It should be apparent, however, that more than one pair of row and column elements can be concurrently connected by actuating additional ones of
20 the first and second MEMS actuators, thereby providing a "one-to-many" connection if so desired.

In order to maintain electrical contact between the contact members 150 without requiring that the respective pair of first and second MEMS actuators
25 be continually actuated, the MEMS switching array 140 of one advantageous embodiment includes latch means for latching the actuator members 148 of the respective pair of first and second MEMS actuator following actuation thereof. The respective pair of first and
30 second MEMS actuators can then be deactuated and the respective contact members will remain electrical contact. As shown in Figures 15 and 17, the latch means of one advantageous embodiment includes a latch member 154, such as a tapered projection, extending
35 outwardly from an end portion of each respective actuator member. The latch means of this embodiment also include a plurality of anchor members 156 formed

on the substrate 142 with one anchor member associated with the latch member of each respective MEMS actuator. As shown, the anchor members also preferably include an outwardly extending tapered projection 156a. The
5 tapered projection of the anchor members cooperates with the latch member of the respective actuator member as the actuator member is advanced to thereby deflect, albeit slightly, the end portion of the actuator member such that the latch member can be advanced beyond the
10 anchor member. Once the latch member is advanced beyond the respective anchor member, the anchor member will serve to prevent the latch member from being retracted, such as upon deactuation of the respective MEMS actuator, due to the cooperable engagement of the
15 anchor member with the latch member.

The anchor member 156 is typically formed of an electroplated metal, such as nickel, that is separated from the substrate 142 by a dielectric layer, such as silicon nitride, and/or a plating base. In
20 order to prevent the end portion of the respective actuator member 148 from deflecting excessively in a direction away from the substrate, the anchor member also preferably includes an arched portion 156b that crosses over the end portion of the actuator member in
25 the same fashion as was illustrated in Figure 16 with respect to a pair of orthogonal actuator members. As shown in Figures 15 and 17, the end of the arched portion opposite the anchor member is preferably attached to another support 158. In one advantageous
30 embodiment, this other support is also typically formed of metal, such as electroplated nickel, that is separated from the substrate by means of a dielectric layer, such as silicon nitride, and/or a plating base.

For embodiments of the MEMS switching array
35 140 that include latch means, the MEMS switching array also preferably includes reset means for unlatching the actuator members 148 such that the respective contact

members 150 separate and no longer make electrical contact in the absence of further actuation of respective ones of the MEMS actuators. As shown in Figures 15 and 17, the reset means preferably includes first and second reset MEMS actuators for resetting the plurality of first and second MEMS actuators, respectively. As shown, the actuator member 162 of the first reset MEMS actuator 160 preferably extends in a lengthwise manner adjacent to and generally perpendicular to the end portions of each of the actuator members of the first MEMS actuators 144. Likewise, the actuator member 166 of the second reset MEMS actuator 164 preferably extends in a lengthwise fashion adjacent to and generally perpendicular to the end portions of each of the actuator members of the second MEMS actuators 146.

In order to prevent the end portion of the actuator member 162 of the first reset MEMS actuator from deflecting excessively in a direction away from the substrate 142, an arched member 162a preferably extends between a pair of anchor members that are positioned upon the substrate such that the arched member crosses over the end portion of the actuator member of the first reset MEMS actuator in the same fashion as was illustrated in Figure 16 with respect to a pair of orthogonal actuator members. Likewise, another arched member 166a preferably extends between a second pair of anchor members that are positioned upon the substrate such that the arched member crosses over the end portion of the actuator member 166 of the first reset MEMS actuator 164.

The actuator member of each of the first and second reset MEMS actuators includes a plurality of reset members 168 spaced along the actuator member and extending outwardly therefrom in a direction toward the switching array 140. In particular, the spacing of the reset members is preferably the same as the spacing of

the respective actuator members that will be reset thereby. According to one advantageous embodiment, the reset members are posts that extend outwardly in a direction generally perpendicular to the actuator member of the respective reset MEMS actuator.

In operation, the reset MEMS actuator is actuated so as to move the respective actuator member such that the reset members 168 will engage the actuator members of the respective MEMS actuators that have been latched. With reference to Figures 15 and 17, for example, actuation of the first reset MEMS actuator 160 moves the respective actuator member 162 downwardly, while actuation of the second reset MEMS actuator 164 moves the respective actuator member 166 to the left. Once engaged, further movement of the actuator member of a reset MEMS actuator will deflect the end portions of the actuator members of the respective MEMS actuators in a direction away from the respective anchor member, thereby disengaging the actuator members. The restoring provided by the arched beams of the respective MEMS actuators will then return the actuator members to an unlatched, neutral position as shown in Figure 15.

As such, the MEMS switching array 140 allows electrical contact to be established in a reliable fashion between respective pairs of the first and second MEMS actuators that define individual row and column elements, respectively. Electrical signals can then be passed via the metallic portions of the respective pair of interconnected MEMS actuators. For example, an electrical signal introduced at one of the spaced apart supports of one of the interconnected MEMS actuators is transmitted via the actuator members and contact members of the respective pair of MEMS actuators to one of the supports of the other one of the interconnected MEMS actuators. Thus, the MEMS switching array of the present invention is

particularly advantageous for telecommunications and other switching applications.

According to another embodiment of the present invention, a MEMS valve 170 is provided in which at least one opening 172a is defined through the substrate 172, typically by bulk silicon micromachining or other conventional processes. According to this embodiment, the MEMS valve includes a MEMS actuator 174 having a valve plate 176 operably coupled to the arched beams 178 and, more preferably, operably coupled to the actuator member 180 such that further arching of the arched beams controllably moves or positions the valve plate relative to the substrate. Typically, the valve plate is formed of an electroplated metal, such as nickel.

As shown in Figure 18, the MEMS actuator 174 is advantageously positioned upon the substrate 172 relative to the opening 172a such that the valve plate 176 at least partially covers the opening and, more preferably, fully covers the opening upon actuation of the MEMS actuator, thereby forming a "normally open" valve. Alternatively, the MEMS actuator can be positioned upon the substrate relative to the opening such that the valve plate covers the opening in the absence of actuation and is removed from the opening only upon actuation of the MEMS actuator, thereby forming a "normally closed" valve.

Upon actuation of the "normally open" MEMS actuator 174 of Figure 18, such as by passing current through the heater 182, the valve plate 176 is moved over the opening 172a in the substrate 172 to close the opening as shown in Figure 19B. As described above in conjunction with a MEMS relay, the MEMS valve 170 also preferably includes means for holding the valve plate in position relative to the opening following actuation of the MEMS actuator. For example, the means for holding the valve plate in position can include means

for applying an electrostatic force between the valve plate and the substrate. As a result of the electrostatic force, the valve plate is deflected toward the substrate so as to be clamped down over the opening, thereby further restricting or preventing fluid flow there through. In order to apply the electrostatic force, a voltage differential can be applied between the valve plate and the substrate or, alternatively, between the valve plate and an electrode 184 formed on or in the portion of the substrate adjacent to and, in some embodiments, surrounding the opening in the same manner to that described above in conjunction with MEMS relays. By continuing to apply the electrostatic force, the valve plate can be held in the closed position over the opening defined by the substrate even if the MEMS actuator is deactuated, thereby further reducing the power requirements of the MEMS valve. Upon releasing the valve plate, however, such as by no longer applying a voltage differential between the valve plate and the substrate, the MEMS actuator returns to the neutral position shown in Figures 18 and 19A in which the opening is uncovered.

In order to provide increased fluid flow, a plurality of openings 172a can be defined by the substrate 172 as shown in Figure 18. According to this advantageous embodiment, the MEMS actuator 174 preferably includes a plurality of valve plates 176 equal in number to the number of openings defined by the substrate. Each of the valve plates is preferably operably coupled to the arched beams 178 and, more preferably, to the actuator member 180 of the MEMS actuator such that movement of the arched beams controllably moves the valve plates with respect to respective ones of the openings. In the embodiment of Figure 18, for example, actuation of the MEMS actuator moves the pair of valve plates over respective ones of the openings defined by the substrate, while

deactuation of the MEMS actuator returns the valve plates to a rest or neutral position in which the openings are uncovered.

Another embodiment of a MEMS valve 170 that
5 provides an even further increased fluid flow through larger openings 172a defined in the substrate 172 is shown in Figures 20 and 21. In this embodiment, the MEMS actuator 174 has a fan-type construction in which each of the valve plates 176 pivots about a pivot point
10 as the arched beams 184 are heated. As shown, the pivot point is typically defined by bearing post 186 extending outwardly from the substrate. Since the openings defined by the substrate of this advantageous embodiment are generally spaced angularly about the
15 bearing post, the plurality of valve plates are preferably coupled to a center plate 188 that is adapted to pivot about the pivot point. As shown, the center plate is typically suspended by means of springs 189 above the substrate.

20 As further shown in Figures 20 and 21, the end portion of the actuator member 190 of the MEMS actuator 174 is preferably connected to the center plate 188 at a point offset from the pivot point. As such, actuation of the MEMS actuator and the resulting
25 movement of the actuator member will pivot the valve plates about the bearing post, thereby moving the valve plates with respect to the respective openings 172a defined by the substrate 172.

In the embodiment of the fan-type MEMS valve
30 170 shown in Figures 20, the MEMS valve is normally open. As such, actuation of the MEMS actuator 174 will rotate the valve plates 176 so as to at least partially cover respective ones of the openings 172a defined by the substrate 172. Alternatively, the fan-type MEMS
35 valve can be normally closed as shown in Figure 21 such that actuation of the MEMS actuator will rotate the valve plates so as to at least partially uncover or

open respective ones of the openings defined by the substrate. As shown in both Figures 20 and 21, the MEMS valve can include at least one stop 177 positioned upon the substrate for contacting a respective valve plate upon actuation of the MEMS valve so as to prevent excessive rotation of the valve plates.

As described above, the MEMS valve 170 of this embodiment can also include means for holding each of the valve plates 176 in position relative to the respective openings 172a even after the MEMS actuator has been deactivated, thereby further reducing the power requirements of the MEMS valve. Although not illustrated, the holding means preferably includes electrodes positioned upon the portion of the substrate 172 surrounding or at least adjacent to a respective opening. As such, the valve plate is preferably slightly larger than the respective opening such that the valve plate can completely cover the opening and a sufficient electrostatic force can be generated between the underlying electrode and the valve plate to restrict or stop fluid flow therethrough.

The various embodiments of the MEMS valve 170 of the present invention reliably control the fluid flow through one or more openings 172a defined in the substrate 172. By controllably covering and uncovering multiple openings, the overall fluid flow supported by the MEMS valve of the present invention is also increased relative to other designs that cover and uncover a single opening since the size of the opening which may be covered by a MEMS valve is generally limited by, among other things, the maximum displacement that the arched beams can apply. In addition, by employing a fan-type design, the amount of displacement provided by movement of the actuator member 190 is multiplied by the ratio of the length b of the valve plates 176 relative to the length a of the lever arm, i.e., the distance by which the connection

of the end portion of the actuator member to the center plate 188 is offset from the pivot point. Since this ratio is typically greater than 1, the fan-type valve of the present invention permits the size of the openings that can be covered and uncovered by the valve plates to be increased.

MEMS structures, including the MEMS actuators, of the present invention provide significant forces and displacements while consuming reasonable amounts of power. As described above, the design of the MEMS actuator of the present invention provides efficient thermal transfer of the heat generated by the heater to the overlying metallic arched beam so as to create further arching of the metallic arched beam. In order to capitalize upon the efficient operation of the MEMS actuator of the present invention, a number of MEMS devices, such as a variety of MEMS relays, MEMS switching arrays and MEMS valves, are also advantageously provided.

Many modifications and other embodiments of the invention will come to mind to one skilled in the art to which this invention pertains having the benefit of the teachings presented in the foregoing descriptions and the associated drawings. Therefore, it is to be understood that the invention is not to be limited to the specific embodiments disclosed and that modifications and other embodiments are intended to be included within the scope of the appended claims. Although specific terms are employed herein, they are used in a generic and descriptive sense only and not for purposes of limitation.

CLAIMS:

1. A microelectromechanical structure comprising:
- 5 a microelectronic substrate;
a heater extending between first and second opposed ends, wherein the first and second ends are disposed on said microelectronic substrate;
spaced apart supports on said microelectronic substrate; and
- 10 a metallic arched beam extending between said spaced apart supports, wherein said metallic arched beam extends over and is spaced from said heater such that heat generated by said heater causes said metallic arched beam to further arch.
- 15 2. A microelectromechanical structure according to Claim 1 wherein said heater comprises:
a core comprising at least partially conductive material having high resistivity; and
a coating comprising a dielectric material
- 20 surrounding said at least partially conductive core, wherein said dielectric coating cooperates with an air gap defined between said metallic arched beam and said heater to electrically isolate said metallic arched beam from said at least partially conductive core.
- 25 3. A microelectromechanical structure according to Claim 2 wherein said at least partially conductive material is selected from the group consisting of polysilicon, titanium and tungsten, and wherein said dielectric material is selected from the
- 30 group consisting of silicon nitride and silicon dioxide.

4. A microelectromechanical structure according to Claim 2 wherein the air gap defined between said metallic arched beam and said heater is less than 5 microns.

5 5. A microelectromechanical structure according to Claim 4 wherein the air gap defined between said metallic arched beam and said heater is between 1 micron and 2 microns, and wherein said dielectric coating covering the portion of said at
10 least partially conductive material that faces said metallic arched beam has a thickness of about 0.5 micron.

6. A microelectromechanical structure according to Claim 1 further comprising a plurality of
15 arched beams formed of nickel.

7. A microelectromechanical structure according to Claim 1 further comprising a lengthwise extending actuator member coupled to said metallic arched beam and extending outwardly therefrom in a
20 first direction, wherein said heater underlies and is aligned with said actuator member in the first direction.

8. A method of fabricating a microelectromechanical structure comprising the steps
25 of:

depositing a sacrificial plating base upon a first surface of a microelectronic substrate;

depositing a photoresist layer upon the sacrificial plating base;

30 patterning the photoresist layer to open one or more windows to the sacrificial plating base, wherein said patterning step comprises defining windows corresponding to a pair of spaced apart supports and an

arched beam extending between the spaced apart supports;

electroplating metal within the windows defined by the photoresist layer to thereby form the pair of spaced apart supports and the arched beam extending between the spaced apart supports;

5 removing the photoresist layer following said electroplating step; and

releasing the arched beam from the microelectronic substrate following removal of the photoresist layer.

10

9. A method according to Claim 8 wherein said releasing step comprises etching at least portions of the sacrificial plating base following removal of the photoresist layer.

15

10. A method according to Claim 8 further comprising the steps of:

depositing an oxide layer on the first surface of the microelectronic substrate; and

20 patterning the oxide layer such that the oxide layer is disposed upon portions of the first surface of the microelectronic substrate that will underlie the arched beam but is not disposed upon portions of the first surface of the microelectronic substrate that will underlie the pair of spaced apart supports,

25

wherein said steps of depositing an oxide layer and patterning the oxide layer are performed prior to said step of depositing a sacrificial plating base, and

30

wherein said releasing step comprises etching the oxide layer to thereby release the arched beam from the microelectronic substrate.

11. A method according to Claim 8 further comprising the step of forming a heater on the first surface of the microelectronic substrate prior to depositing the sacrificial plating base thereon.

5 12. A method according to Claim 11 further comprising the step of etching a cavity in the portion of the microelectronic substrate underlying the heater that opens through the first surface thereof such that portions of the heater are further thermally isolated
10 from the microelectronic substrate.

 13. A microelectromechanical relay comprising:
 a microelectronic substrate;
 a first pair of contacts on said
15 microelectronic substrate; and
 a first microelectromechanical actuator on said microelectronic substrate for controllably establishing electrical contact between said first pair of contacts, said first microelectromechanical actuator
20 comprising:
 spaced apart supports on said microelectronic substrate;
 an arched beam extending between said spaced apart supports;
25 an actuator member operably coupled to said arched beam and extending outwardly therefrom toward said first pair of contacts; and
 means for heating said arched beam to cause further arching of said beam such that said
30 actuator member moves between an open position in which said actuator member is spaced from said first pair of contacts and a closed position in which said actuator member contacts said first pair of contacts and establishes an electrical connection therebetween.

14. A microelectromechanical relay according to Claim 13 wherein said actuator member comprises:

a lengthwise extending portion coupled to said arched beam for movement therewith upon heating of said arched beam; and

an enlarged contact portion, responsive to movement of said lengthwise extending portion, for contacting said first pair of contacts.

15. A microelectromechanical relay according to Claim 14 wherein said lengthwise extending portion and said enlarged contact portion of said actuator member are a unitary structure.

16. A microelectromechanical relay according to Claim 14 wherein said lengthwise extending portion and said enlarged contact portion of said actuator member are separate structures, and wherein said lengthwise extending portion contacts said enlarged contact portion upon movement of said lengthwise extending portion in response to heating of said arched beam.

17. A microelectromechanical relay according to Claim 13 further comprising means for holding said actuator member in position following heating of said arched beam and movement of said actuator member.

18. A microelectromechanical relay according to Claim 17 wherein said means for holding said actuator member in position comprises means for applying an electrostatic force between said actuator member and said microelectronic substrate to thereby hold at least a portion of said actuator member against said microelectronic substrate.

19. A microelectromechanical relay according to Claim 17 further comprising at least one retaining member on said microelectronic substrate and underlying said actuator member following movement of said
5 actuator member in response to heating of said arched beam, wherein said actuator member includes a lower surface facing said microelectronic substrate that defines at least one recess for cooperably receiving a respective retaining member as said actuator member is
10 held in position.

20. A microelectromechanical relay according to Claim 13 further comprising latch means for latching the actuator member of the first microelectromechanical actuator following actuation thereof such that
15 electrical contact is maintained between the first pair of contact members in the absence of further actuation.

21. A microelectromechanical relay according to Claim 20 wherein said latch means comprises:
a projection extending outwardly from the
20 actuator member of said first microelectromechanical actuator; and
a latch member for cooperably engaging the projection upon actuation of said first microelectromechanical actuator.

22. A microelectromechanical relay according to Claim 21 further comprising reset means for unlatching the actuator member of the first microelectromechanical actuator such that electrical
25 contact is no longer maintained between the first pair of contact members in the absence of further actuation
30 of the first microelectromechanical actuator.

23. A microelectromechanical relay according to Claim 22 wherein said reset means comprises a second

microelectromechanical actuator having an actuator member that includes said latch member such that actuation of the second microelectromechanical actuator unlatches the actuator member of the first
5 microelectromechanical actuator.

24. A microelectromechanical relay according to Claim 13 wherein said heating means comprises means for externally heating said arched beam.

25. A microelectromechanical relay according to Claim 13 further comprising a second
10 microelectromechanical actuator on a portion of said microelectronic substrate opposite said first microelectromechanical actuator relative to said first pair of contacts, wherein said second
15 microelectromechanical actuator controllably disengages said actuator member of said first microelectromechanical actuator from said first pair of contacts, and wherein said second microelectromechanical actuator comprises:
20 spaced apart supports on said microelectronic substrate;
an arched beam extending between said spaced apart supports;
an actuator member operably coupled to said
25 arched beam and extending outwardly therefrom toward said first pair of contacts; and
means for heating said arched beam to cause further arching of said beam such that said actuator member contacts the actuator member of said first
30 microelectromechanical actuator and disengages the actuator member of said first microelectromechanical actuator from said first pair of contacts.

26. A microelectromechanical relay according to Claim 13 further comprising first and second field

intensification structures electrically connected to respective ones of said first pair of contacts and disposed in a facing relationship to thereby define a discharge gap in order provide overvoltage protection.

5 27. A microelectromechanical relay according to Claim 26 wherein each field intensification structure comprises at least one pointed projection extending toward the other field intensification structure to thereby define the discharge gap.

10 28. A microelectromechanical relay for alternately connecting first and second pairs of contacts, the microelectromechanical relay comprising:
 a microelectronic substrate;
 first and second pairs of contacts on said
15 microelectronic substrate;
 first and second microelectromechanical actuators on said microelectronic substrate, wherein each microelectromechanical actuator comprises:
 spaced apart supports on said
20 microelectronic substrate;
 an arched beam extending between said spaced apart supports; and
 an actuator member operably coupled to said arched beam and extending outwardly therefrom,
25 wherein said actuator member of said first microelectromechanical actuator cooperably engages said actuator member of said second microelectromechanical actuator upon actuation of said first microelectromechanical actuator such that electrical
30 contact is established between said first pair of contacts if neither microelectromechanical actuator is actuated and such that electrical contact is established between said second pair of contacts if only said second microelectromechanical actuator is
35 actuated.

29. A microelectromechanical relay according to Claim 28 wherein the actuator member of said second microelectromechanical actuator includes an enlarged head portion disposed between said first and second
5 pairs of contacts for alternately contacting said first and second pairs of contacts.

30. A microelectromechanical relay according to Claim 28 wherein an end portion of the actuator member of said second microelectromechanical actuator
10 comprises a sleeve opening through the end thereof, and wherein an end portion of the actuator member of said first microelectromechanical actuator comprises an engagement portion for insertion through the end of said sleeve upon actuation of said first
15 microelectromechanical actuator such that the actuator members of said first and second microelectromechanical actuators remain cooperably engaged following deactuation of said first microelectromechanical actuator.

31. A microelectromechanical relay according to Claim 28 wherein the arched beams of both said first and second microelectromechanical actuators are arched
20 in the same direction.

32. A microelectromechanical switching array
25 comprising:
a microelectronic substrate;
a plurality of first and second microelectromechanical actuators positioned on said microelectronic substrate such that said plurality of
30 first microelectromechanical actuators define respective row elements and said plurality of second microelectromechanical actuators define respective column elements, wherein each microelectromechanical actuator comprises:

spaced apart supports on said
microelectronic substrate;

an arched beam extending between said
spaced apart supports;

5 an actuator member operably coupled to
said arched beam and extending outwardly therefrom; and
a plurality of contact members spaced
along said actuator member and extending outwardly
therefrom,

10 wherein actuation of a respective pair of
first and second microelectromechanical actuators moves
the respective actuator members and establishes
electrical contact between respective contact members
such that a continuous electrical path extends between
15 the respective pair of first and second
microelectromechanical actuators.

33. A microelectromechanical switching array
according to Claim 32 further comprising latch means
for latching the actuator members of the respective
20 pair of first and second microelectromechanical
actuators following actuation thereof such that
electrical contact is maintained between the respective
contact members in the absence of further actuation.

34. A microelectromechanical switching array
25 according to Claim 33 wherein said latch means
comprises:

a latch member extending outwardly from each
respective actuator member; and

a plurality of anchor members on said
30 microelectronic substrate, wherein one anchor member is
associated with each of said first and second
microelectromechanical actuators for cooperably
engaging the latch member upon actuation of said
respective microelectromechanical actuator.

35. A microelectromechanical switching array according to Claim 33 further comprising reset means for unlatching the actuator members of the respective pair of first and second microelectromechanical
5 actuators such that the respective contact members separate and no longer make electrical contact in the absence of further actuation of the respective pair of first and second microelectromechanical actuators.

36. A microelectromechanical switching array
10 according to Claim 34 further comprising first and second reset actuators for resetting said plurality of first and second microelectromechanical actuators, respectively, wherein each reset actuator comprises:
spaced apart supports on said microelectronic
15 substrate;
an arched beam extending between said spaced apart supports;
an actuator member operably coupled to said arched beam and extending outwardly therefrom; and
20 a plurality of reset members spaced along said actuator member and extending outwardly therefrom, wherein said plurality of reset members engage respective actuator members of said
microelectromechanical actuators upon actuation of said
25 reset actuator such that said latch portions of said actuator members are disengaged from said respective anchor members.

37. A microelectromechanical valve comprising:
30 a microelectronic substrate defining at least one opening therethrough;
a microelectromechanical actuator on said microelectronic substrate, said microelectromechanical actuator comprising:

spaced apart supports on said
microelectronic substrate;

an arched beam extending between said
spaced apart supports;

5 a valve plate operably coupled to said
arched beam and adapted to at least partially cover
said opening; and

means for heating said arched beam to
cause further arching of said beam such that said valve
10 plate is moved relative to said opening to thereby
controllably adjust the portion of said opening covered
by said valve plate.

38. A microelectromechanical valve according
to Claim 37 wherein said microelectromechanical
15 actuator further comprises an actuator member operably
coupled to said arched beam for movement therewith, and
wherein said valve plate is operably coupled to said
actuator member.

39. A microelectromechanical valve according
20 to Claim 38 wherein said microelectronic substrate
defines a plurality of openings, and wherein said
microelectromechanical actuator further comprises a
plurality of valve plates operably coupled to said
arched beam and adapted to at least partially cover
25 respective ones of said openings.

40. A microelectromechanical valve according
to Claim 38 wherein said valve plate pivots about a
pivot point as said arched beam is heated to thereby
controllably adjust the portion of said opening covered
30 by said valve plate.

41. A microelectromechanical valve according
to Claim 40 further comprising a bearing post extending
outwardly from said microelectronic substrate, wherein

said valve plate comprises an elongate plate that pivots about said bearing post as said arched beam is heated.

42. A microelectromechanical valve according to Claim 41 wherein said microelectronic substrate defines a plurality of openings spaced angularly about said bearing post, and wherein said microelectromechanical valve further comprises a plurality of valve plates operably coupled to said arched beam and adapted to at least partially cover respective ones of said openings by pivoting about said bearing post as said arched beam is heated.

43. A microelectromechanical valve according to Claim 37 further comprising means for holding said valve plate in position relative to said opening following heating of said arched beam.

44. A microelectromechanical valve according to Claim 43 wherein said means for holding said actuator member in position comprises means for applying an electrostatic force between said valve plate and said microelectronic substrate.

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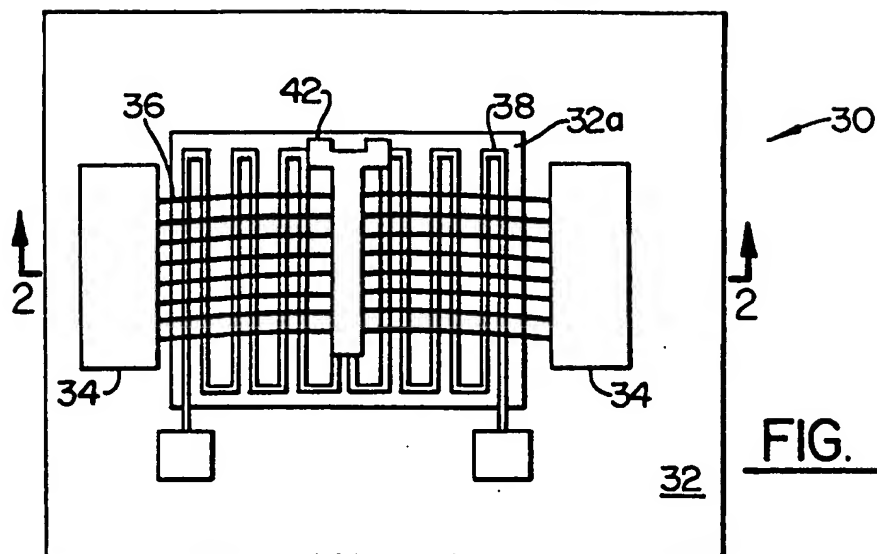


FIG. 1.

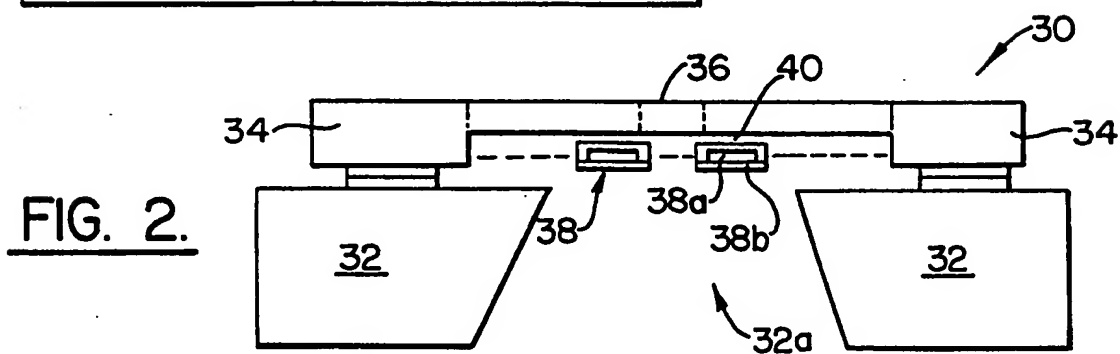


FIG. 2.

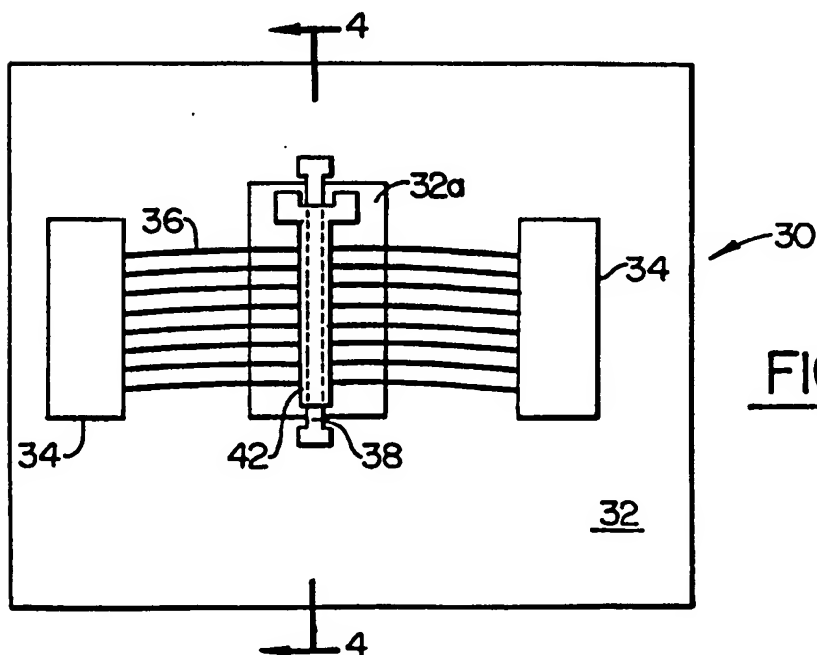
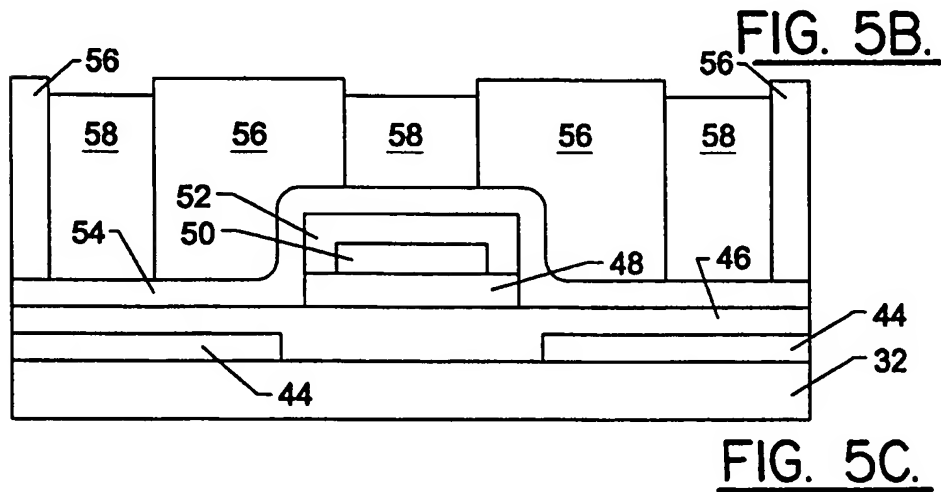
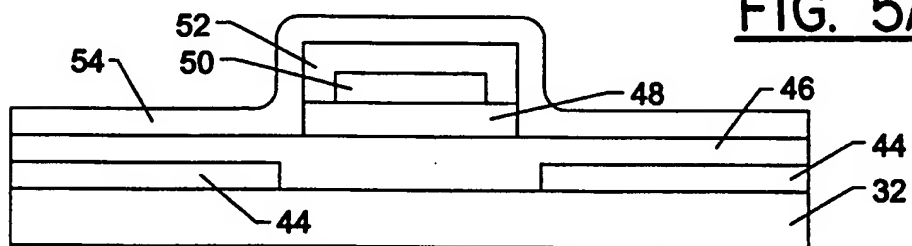
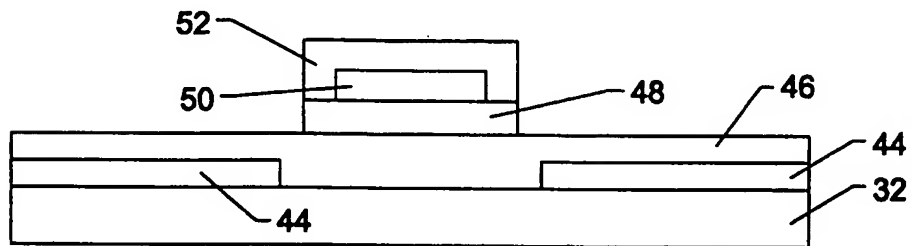
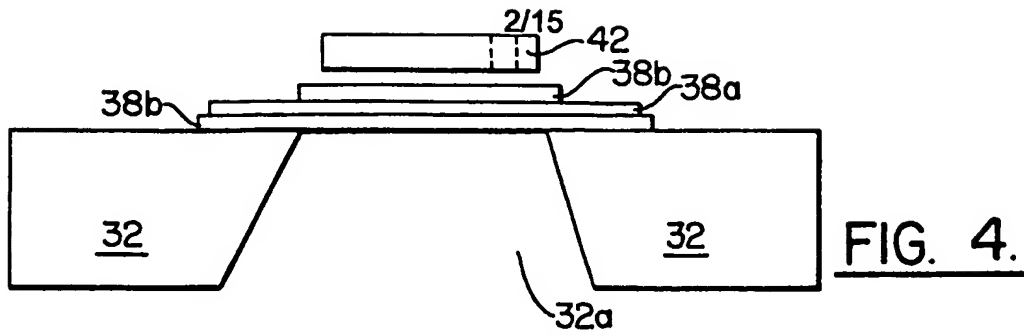
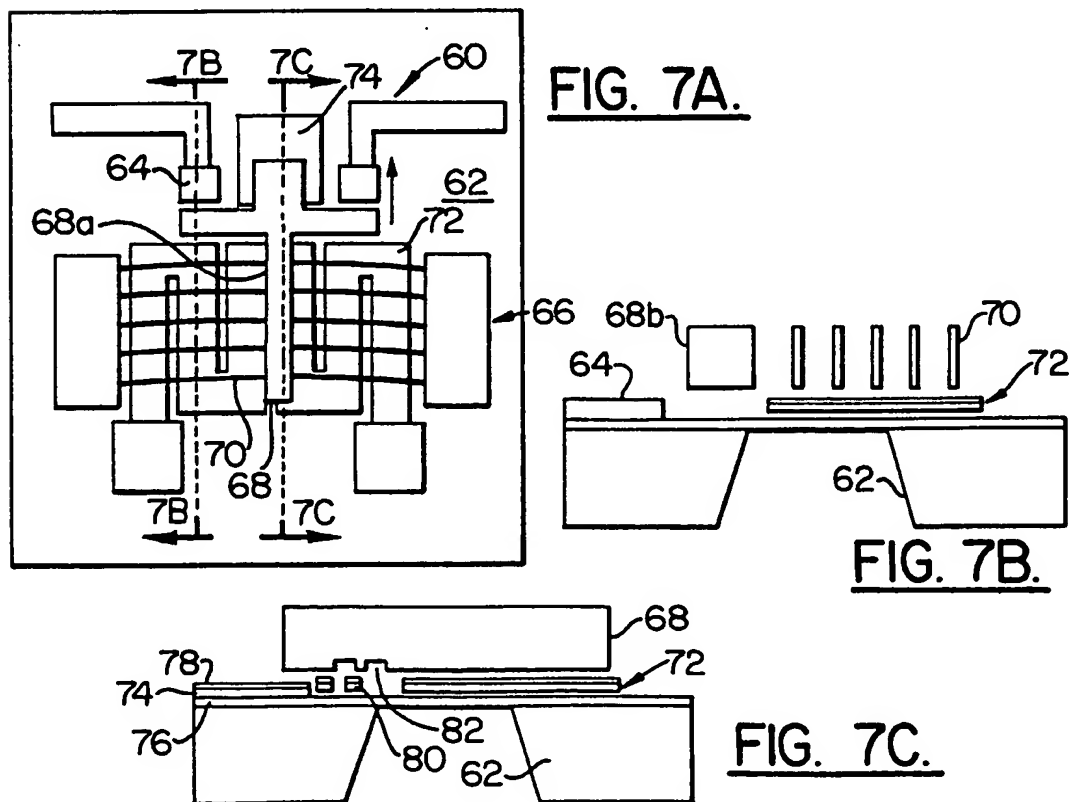
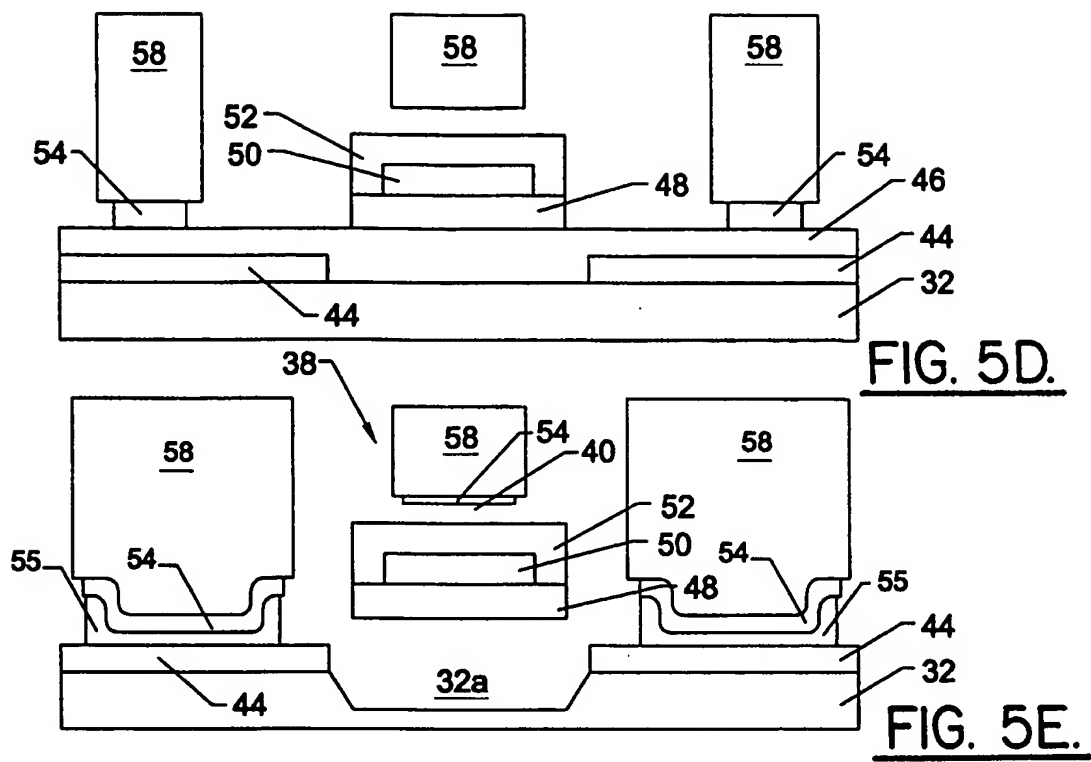


FIG. 3.



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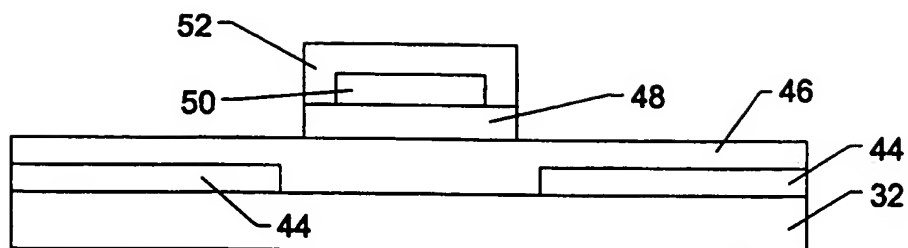


FIG. 6A.

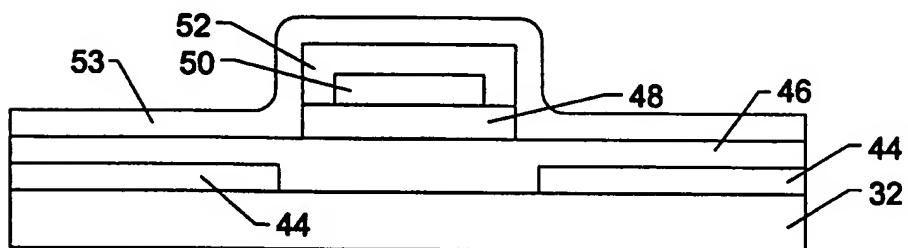


FIG. 6B.

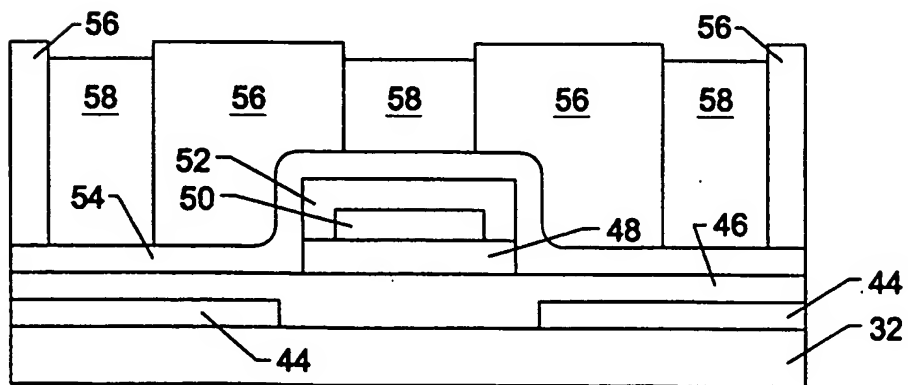


FIG. 6C.

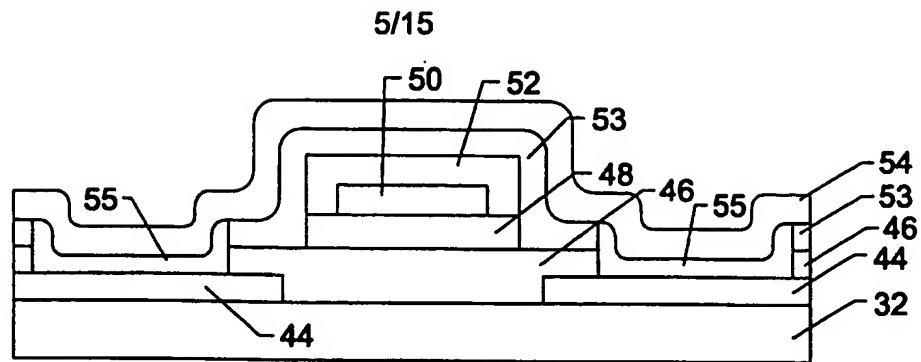


FIG. 6D.

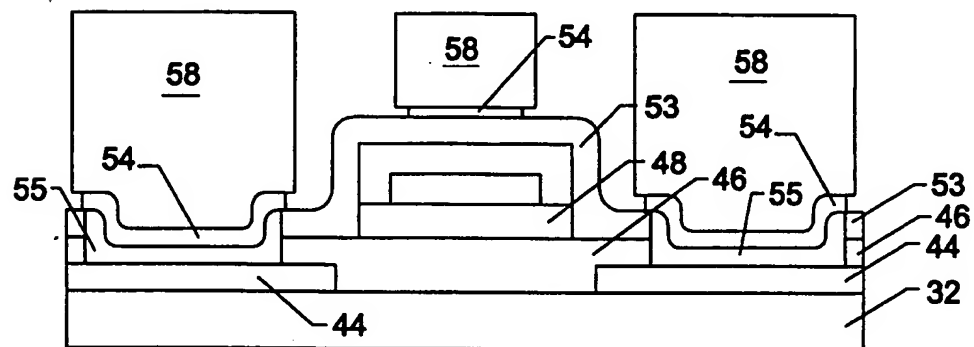


FIG. 6E.

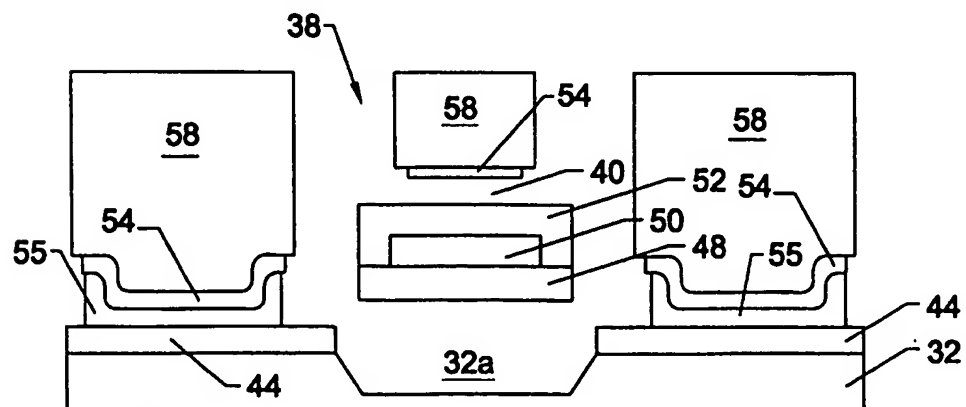


FIG. 6F.

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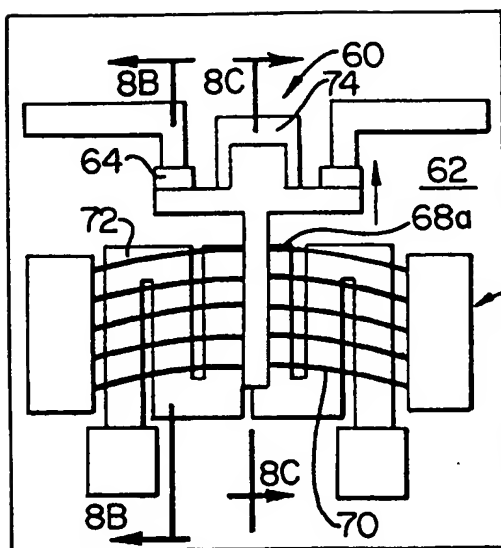


FIG. 8A.

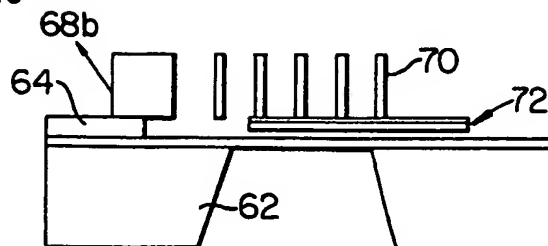


FIG. 8B.

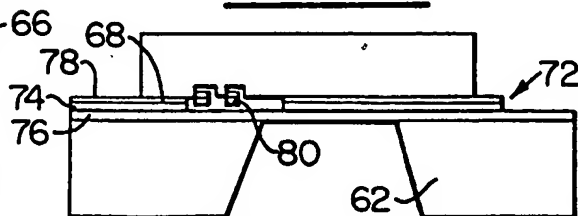


FIG. 8C.

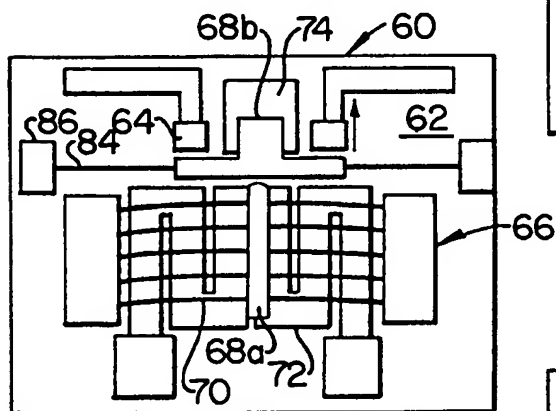


FIG. 9A.

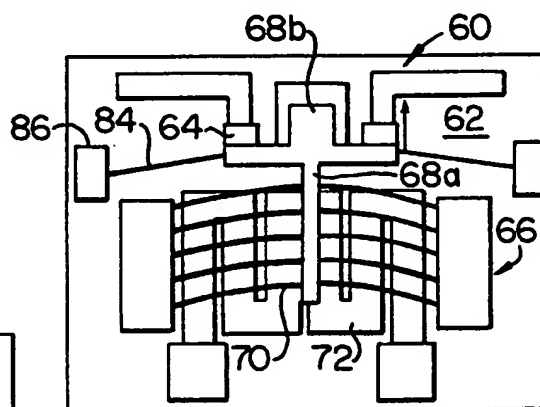


FIG. 9B.

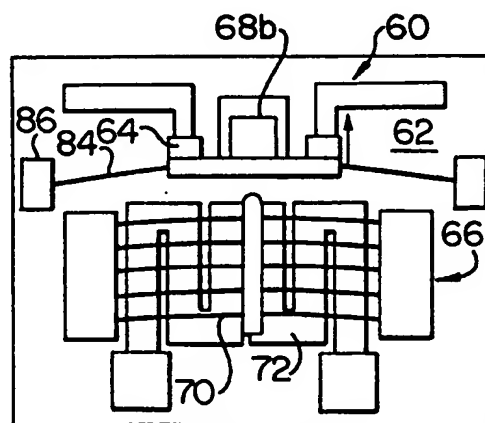
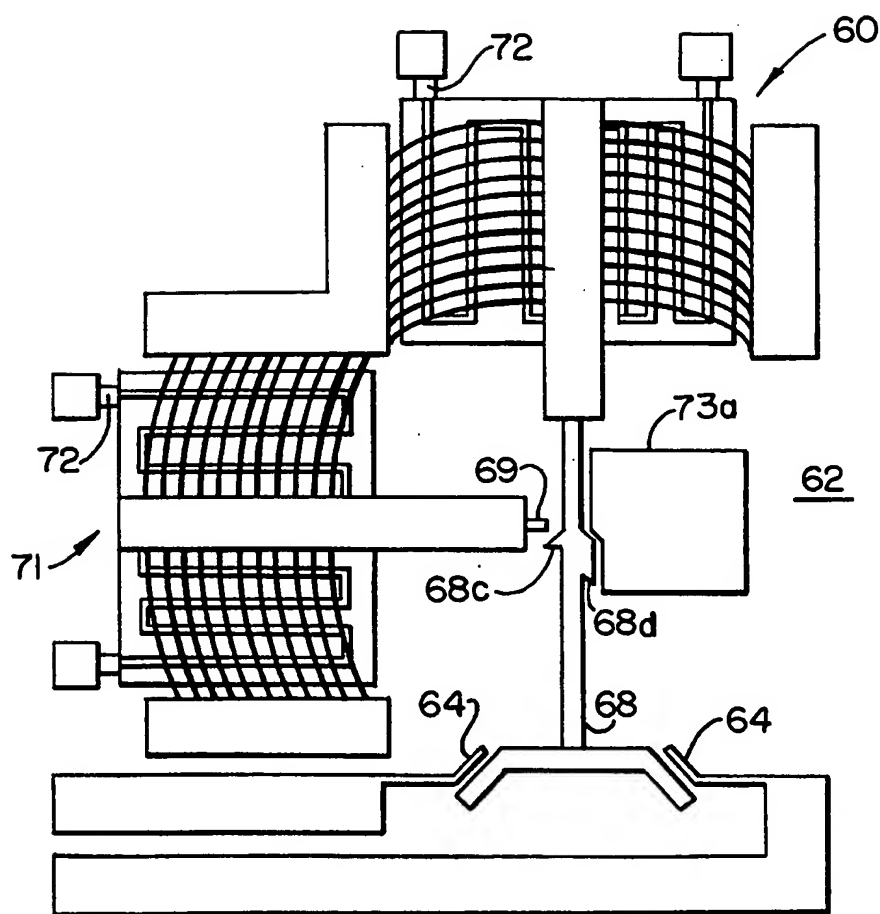


FIG. 9C.

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FIG. II.

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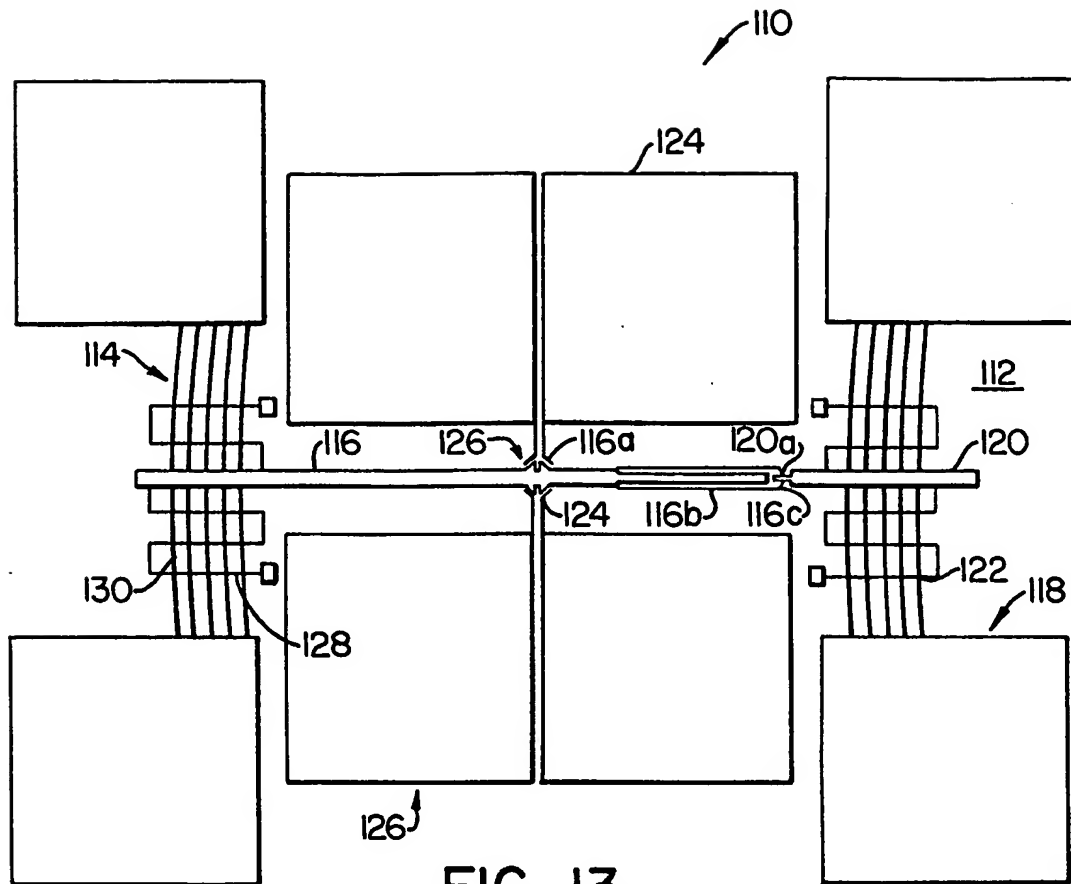


FIG. 13.

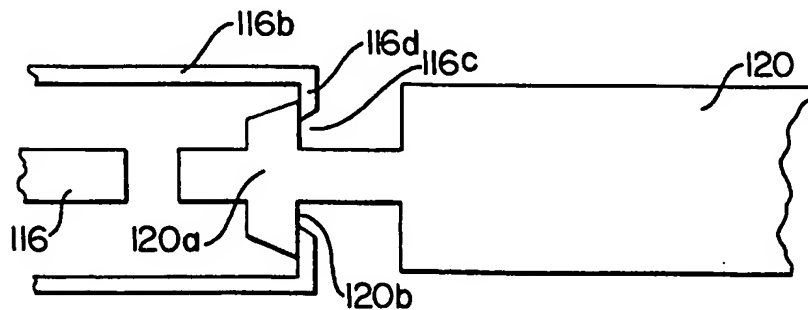
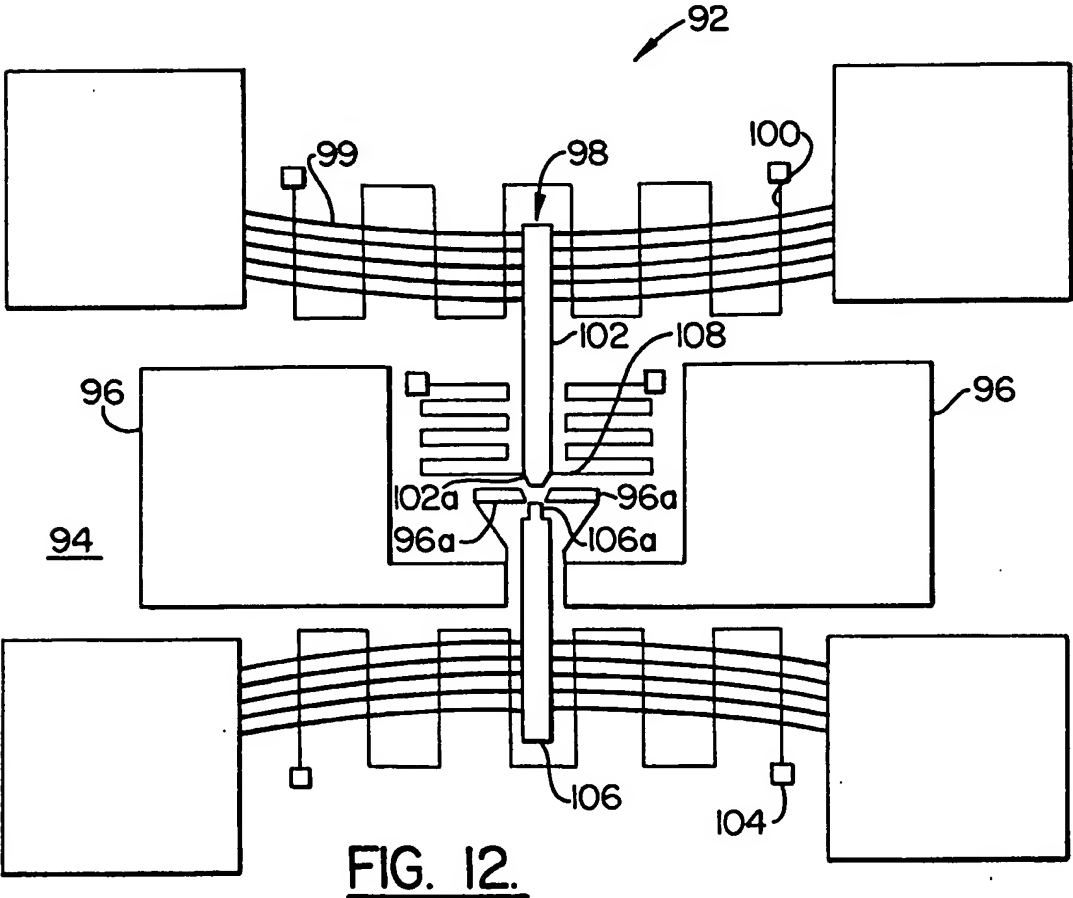
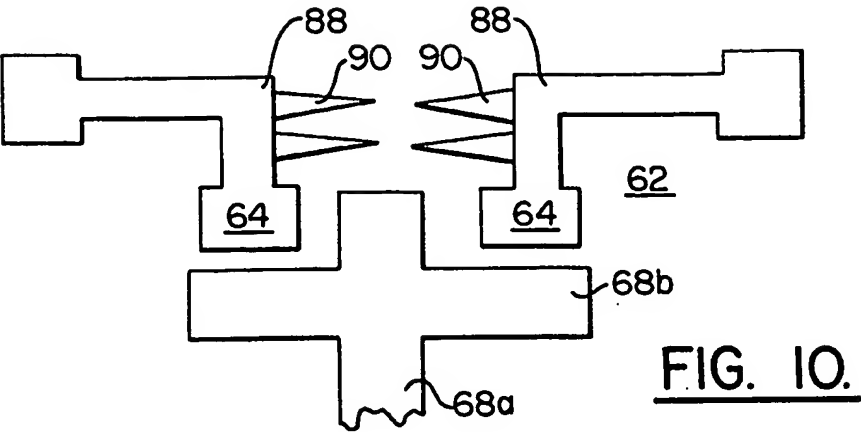
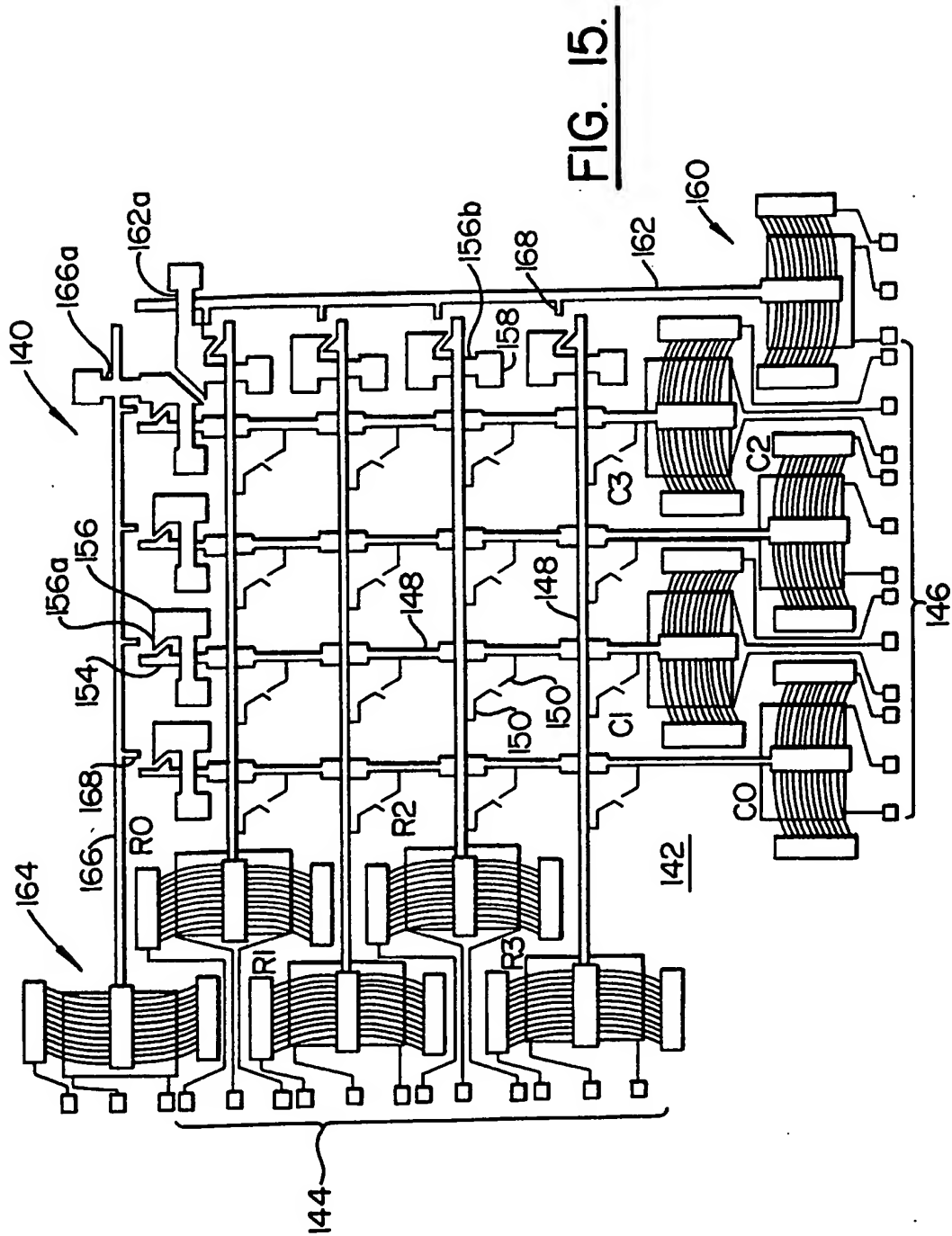


FIG. 14.

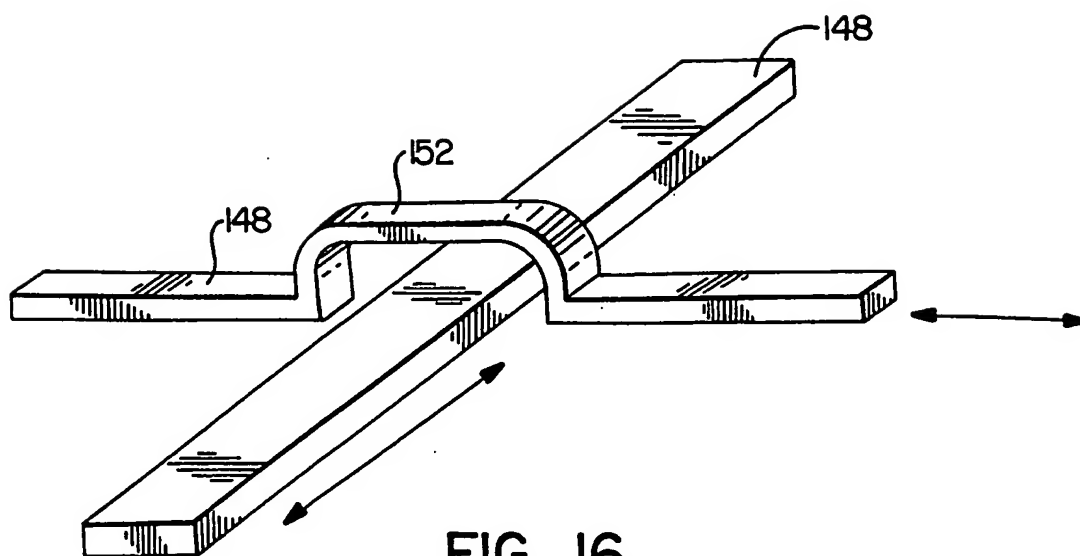
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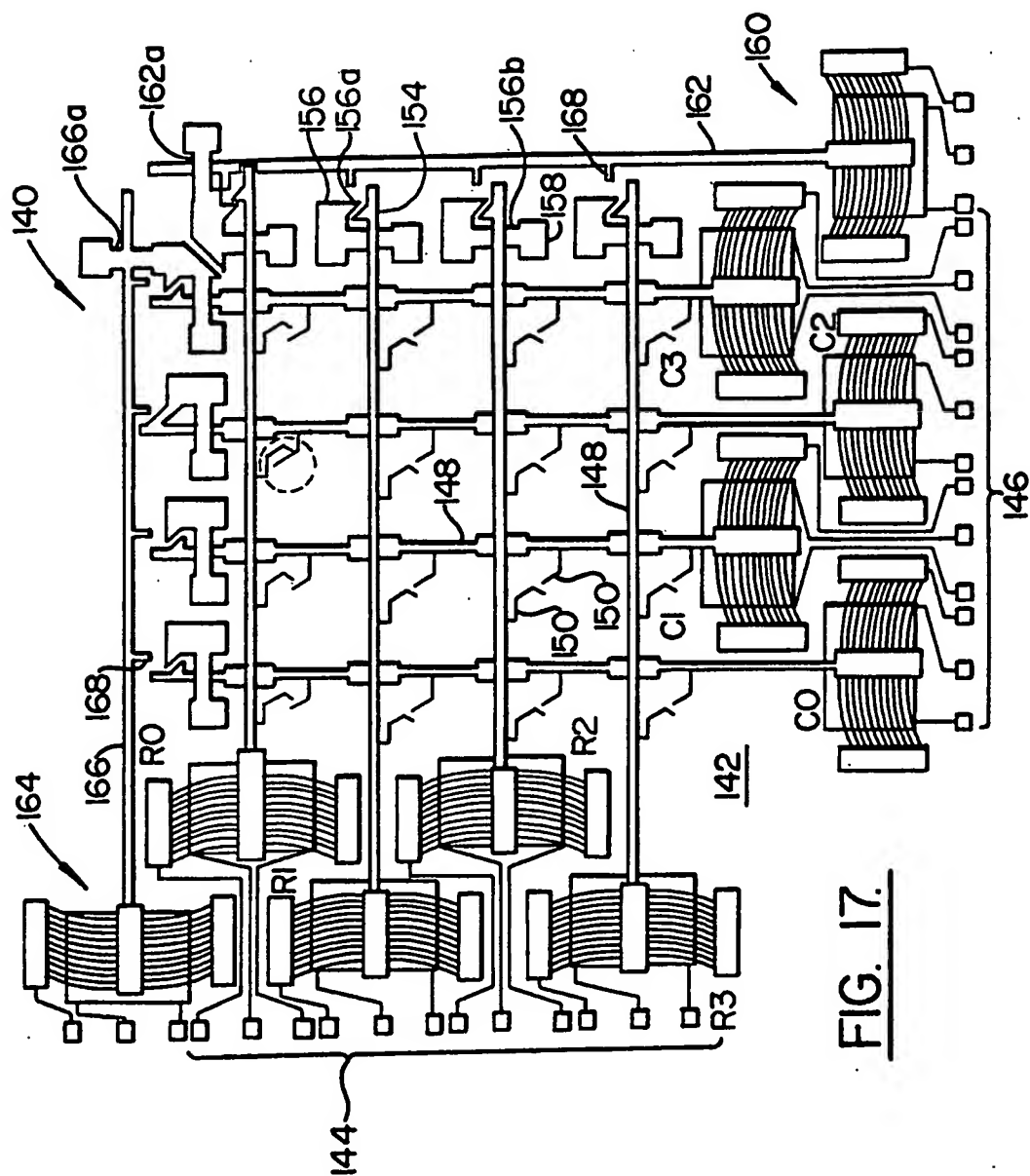
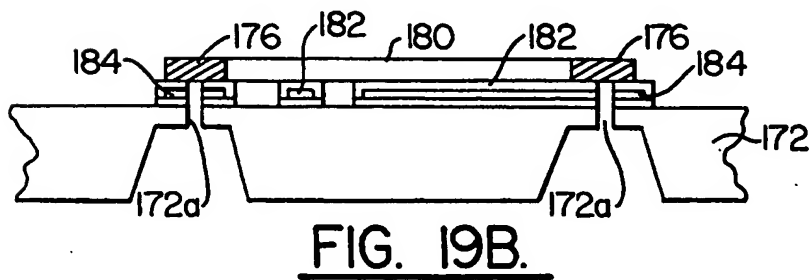
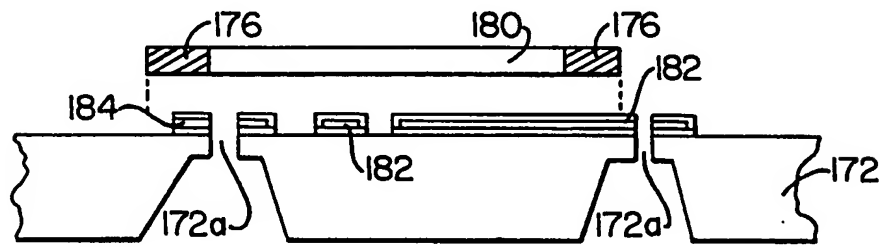
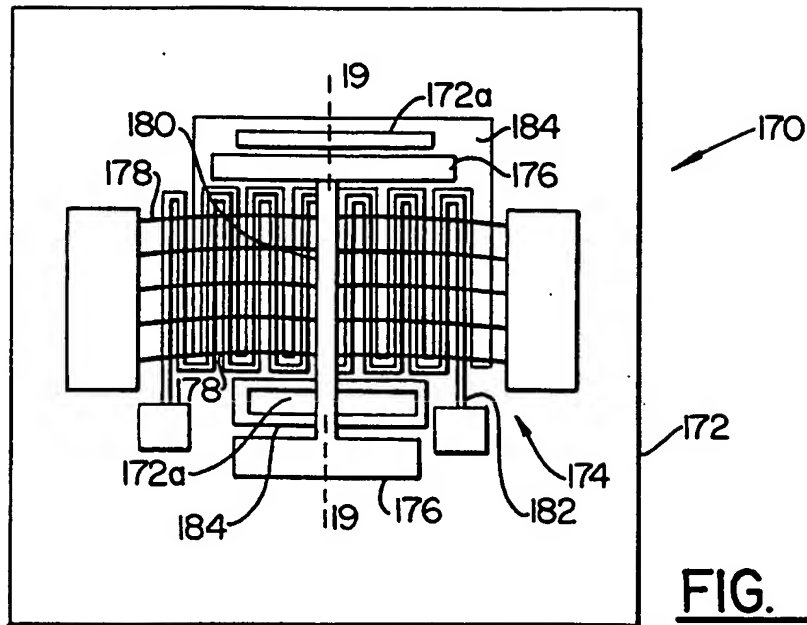


FIG. 17.

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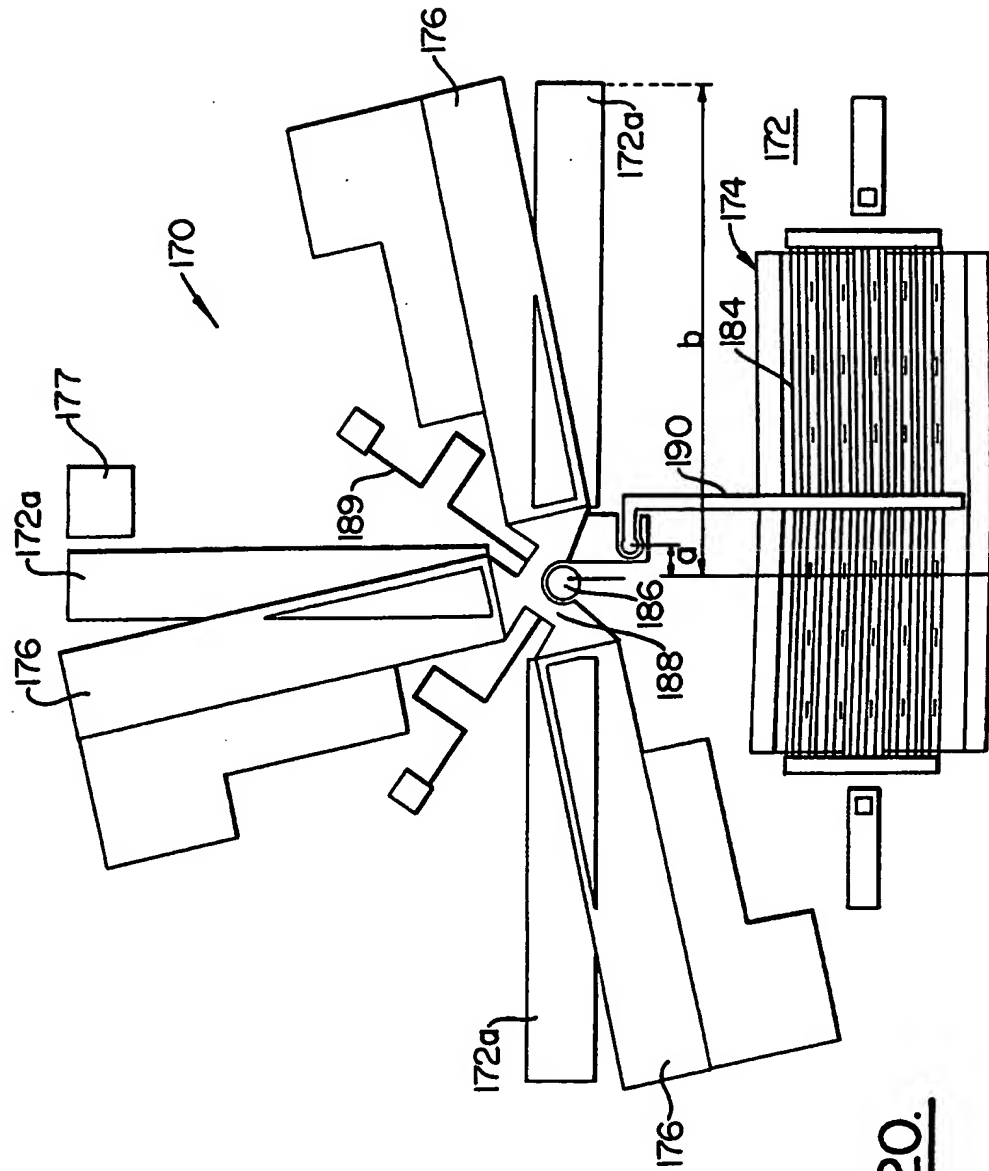
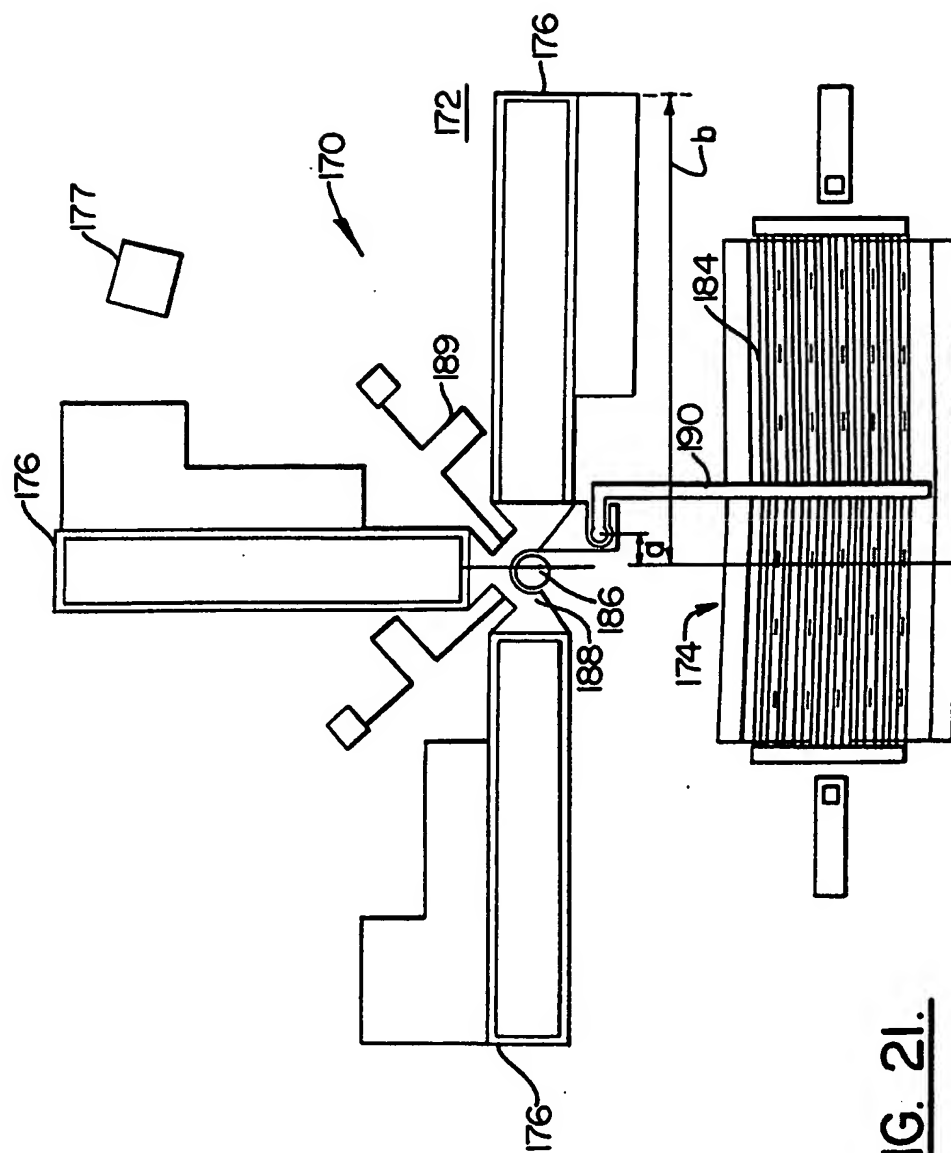


FIG. 20.



INTERNATIONAL SEARCH REPORT

Int. lional Application No

PCT/US 98/18038

A. CLASSIFICATION OF SUBJECT MATTER
IPC 6 H01H61/00 F15C5/00

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

IPC 6 H01H

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	EP 0 478 956 A (KERNFORSCHUNGSZ KARLSRUHE) 8 April 1992 see column 2, line 30 - column 4, line 57 ---	1-8,13, 28,32,37
A	DE 38 09 597 A (FRAUNHOFER GES FORSCHUNG) 5 October 1989 see the whole document ---	1
A	US 5 467 068 A (FIELD LESLIE A ET AL) 14 November 1995 see the whole document ---	1-8,13, 28
A	EP 0 469 749 A (HEWLETT PACKARD CO) 5 February 1992 see claims 1,2 ---	37
A	EP 0 665 590 A (CANON KK) 2 August 1995 see claims 12-38 ---	8-12
-/--		

☒ Further documents are listed in the continuation of box C.

☒ Patent family members are listed in annex.

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Date of the actual completion of the international search

15 January 1999

Date of mailing of the international search report

21/01/1999

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INTERNATIONAL SEARCH REPORT

International Application No

PCT/US 98/18038

C.(Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT

Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	US 5 475 318 A (MARCUS ROBERT B ET AL) 12 December 1995 cited in the application see the whole document ---	1
A	KLAASSEN E H ET AL: "SILICON FUSION BONDING AND DEEP REACTIVE ION ETCHING: A NEW TECHNOLOGY FOR MICROSTRUCTURES" SENSORS AND ACTUATORS A, vol. 52, no. 1/03, March 1996, pages 132-139, XP000483098 cited in the application see the whole document -----	1

INTERNATIONAL SEARCH REPORT

Information on patent family members

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US 5475318 A	12-12-1995	NONE	